



## Review

Current trending and beyond for solar-driven water splitting reaction on WO<sub>3</sub> photoanodes

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## ABSTRACT

This review shows the importance of WO<sub>3</sub> photoanode as a potentially low-cost, efficient, stable, and photoactive material for light-driven water splitting. For such, this manuscript aims to review the most recent publications regarding the strategies to improve the photoelectroactivity of WO<sub>3</sub> films for water oxidation. In addition, this review aims to graphically highlight and discuss the general trendings of the photocurrent density response and stability test of the recent outstanding studies in the literature for photoelectrochemical water splitting application. The strategies covered in this review will not only concern the WO<sub>3</sub> morphology and crystal plane growth, but also the many arrangements possibilities to improve the WO<sub>3</sub> efficiency for water photoelectrooxidation, such as defect engineering based on oxygen vacancies, doping, decorations, and homo and heterojunctions. All these strategies are compared by the photocurrent density results and by the stability of these photocatalysts. The best results in this sense were observed in cases where the use of heterojunction was applied together with a desired morphology and crystal plane of the WO<sub>3</sub> photoanode. However, the modifications that caused a decrease in the photocurrent density reaching values that are even lower than the pure WO<sub>3</sub> were also discussed. In this way, this review intends to improve the knowledge about the synthesis and design of WO<sub>3</sub> photoanodes to further obtain an efficient photocatalyst to minimize the recombination losses or losses across the interfaces and improve the photoelectroactivity for water splitting in the large-scale application.

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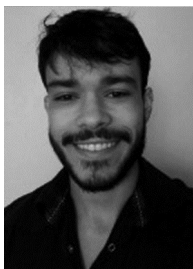
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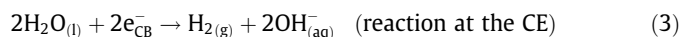
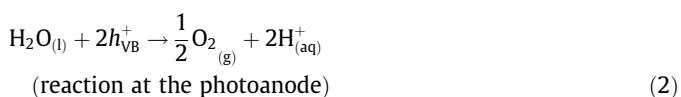
## 1. Introduction

The global environmental implications caused by the ever-growing use of fossil fuels have challenged scientists to develop new technologies to exploit alternative and clean sources of energy that above all can follow the twelve principles of green chemistry [1]. Among the new technologies being studied, photoelectrochemical (PEC) cells stand out as one of the most sustainable and promising approaches to obtaining a clean energy carrier, i.e., dihydrogen ( $\text{H}_2$ ), via solar-driven water splitting [2,3]. By definition, a PEC cell is defined as a device for the conversion of radiant energy or solar energy into chemical energy, namely energy stored in chemical bonds. The basic configuration of a PEC cell consists of a photoelectrode, namely an n-type (photoanode) or p-type (photocathode) semiconductor, and a counter electrode (CE), which is usually a metal (e.g., Pt). These electrodes are immersed in an electrolyte containing a suitable redox pair and connected by an external circuit that may have an external bias to facilitate carrier separation [4]. Concerning the operation of a PEC cell for water photoelectrooxidation application (cf. Fig. 1), the first step consists of impinging light ( $h\nu > E_g$ ) over a photoanode (n-type semiconductor) to photogenerate electrons in the conduction band ( $e_{\text{CB}}^-$ ) and holes in the valence band ( $h_{\text{VB}}^+$ ), Eq. (1) [5].



where  $h\nu$  is the photon energy to generate  $e_{\text{CB}}^-$  and  $h_{\text{VB}}^+$  in the photoanode.

Owing to the built-in electric field or the (quasi-)Fermi level gradient in the space charge region (SCR) of the photoanode and the additional bias input, the photogenerated  $e_{\text{CB}}^-$  and  $h_{\text{VB}}^+$  are spatially separated by migration [5]. The  $h_{\text{VB}}^+$  migrates towards the photoanode|electrolyte interface to oxidize water into dioxygen ( $\text{O}_2$ ), Eq. (2), and the  $e_{\text{CB}}^-$  are transferred to the CE|electrolyte interface via the external circuit to reduce water to  $\text{H}_2$ , Eq. (3) (adapted from [4,6]).



Combining the half-reactions described by Eqs. (2) and (3) with Eq. (1), it is obtained the overall water splitting reaction as shown by Eq. (4).

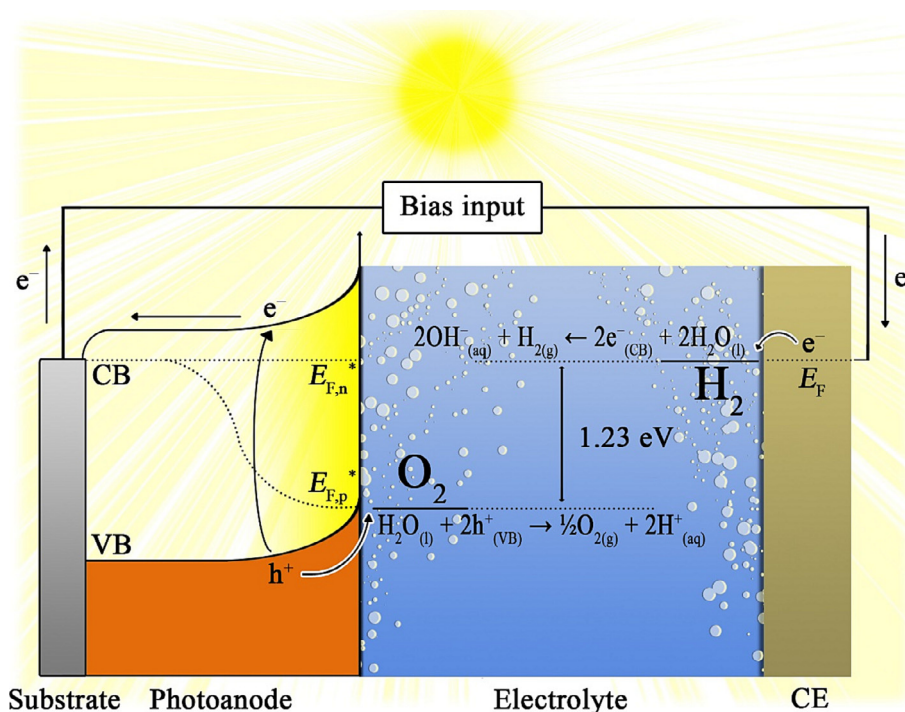


At a neutral electrolyte, water oxidation and reduction have potential values of 0.83 and  $-0.40$  V vs. standard hydrogen electrode (SHE) for the half-reactions given by Eqs. (2) and (3), respectively, and that provides an electrochemical cell voltage ( $\Delta E$ ) of  $-1.23$  V for the overall water splitting reaction (see Eq. (4)). This  $\Delta E$  can be correlated to the Gibbs free energy change ( $\Delta G$ ) of the overall water splitting process via Eq. (5) [7].

$$\Delta G = -nF\Delta E \quad (5)$$

where  $n$  is the number of electrons in the balanced electrode reaction (2 electrons) and  $F$  is the Faraday constant ( $96485.3 \text{ C mol}^{-1}$ ).

Employing Eq. (5) and considering the standard conditions (unit activity and pressure of 1 bar) and temperature of 298.15 K, one has a  $\Delta G$  of  $237 \text{ kJ mol}^{-1}$  for the overall water splitting reaction [7]. Since the  $\Delta G > 0$ , this indicates that the overall process of splitting water into  $\text{O}_2$  and  $\text{H}_2$  (vide Eq. (4)) is non-spontaneous and requires at least an  $\Delta E$  of  $-1.23$  V for its occurrence. In terms of energy, it is equivalent to 1.23 eV, meaning that a semiconductor should theoretically feature bandgap energy ( $E_g$ ) of 1.23 eV to light-driven water splitting [7]. However, for practical applications, the  $E_g$  should be higher than 1.23 eV to overcome the thermodynamic and kinetics losses [8]. Thermodynamic losses may be linked to several factors such as recombination and/or internal resistances to the transport of carriers in the semiconductor [9], while the kinetic losses are associated with the overpotential needed for the hydrogen evolution reaction (HER) and oxygen evolution reaction (OER) that take place at the electrode|electrolyte interface [10]. These overpotentials arise due to activation barriers for the elementary steps, mass transport in the solution phase, junction potential, and resistance to the flow of current inside the electrodes [11]. Taking into consideration all these losses, a semicon-



**Fig. 1.** Schematic representation of a PEC cell comprised of a photoanode and a CE under operation in a generic neutral pH medium. VB is the valence band, CB is the conduction band,  $E_F$  is the Fermi level, and  $E_{F,p}^*$  and  $E_{F,n}^*$  are the quasi-Fermi level of holes and electrons, respectively.

ductor should have a  $E_g$  of approximately 2 eV to ensure that the overall solar-driven water splitting can proceed efficiently [10].

Another interesting topic to mention is that the occurrence of OER on a photoanode (see Eq. (2)) generates an anodic photocurrent density ( $\Delta j_{ph}$ ) signal which can be used as a diagnostic tool to evaluate the PEC cell performance. In addition to the anodic  $\Delta j_{ph}$  response, there are efficiency metrics that can be employed to assess the PEC performance of a photoelectrode, namely photoanode or photocathode. Some of the efficiencies include the applied bias photon-to-current efficiency (ABPE), incident photon-to-current efficiency (IPCE), and absorbed photon-to-current efficiency (APCE), which are given by Eqs. (6), (7), and (8) [8], respectively. Strictly speaking, IPCE and APCE are identical to external quantum efficiency (EQE) and internal quantum efficiency (IQE), respectively.

$$ABPE = \left[ \frac{|\Delta j_{ph}| (1.23 - E) \eta_F}{P_{total}} \right]_{AM1.5G} \quad (6)$$

$$IPCE = EQE = \frac{|\Delta j_{ph}| hc}{P_{mono} \lambda} \quad (7)$$

$$APCE = IQE = \frac{|\Delta j_{ph}| hc}{P_{mono} \lambda (1 - 10^{-A})} \quad (8)$$

where  $E$  is the applied bias or potential,  $\eta_F$  is the Faradaic efficiency,  $P_{total}$  is the irradiance ( $100 \text{ mW cm}^{-2}$  for one sun condition),  $h$  is the Planck constant ( $6.626 \times 10^{-34} \text{ J s}$ ),  $c$  is the speed of light ( $2.998 \times 10^8 \text{ m s}^{-1}$ ),  $P_{mono}$  is the calibrated and monochromatic irradiance,  $\lambda$  is the monochromatic light wavelength, and  $A$  is the absorbance of the photoelectrode at a certain  $\lambda$  value.

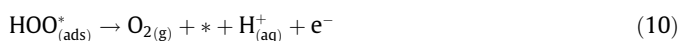
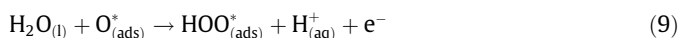
Even though the ABPE, IPCE, and APCE can provide useful information on the photoelectrode and interface properties, it is important to keep in mind that these efficiency metrics are only considered as diagnostics. For mainstream efficiency reporting, the only valid benchmark efficiency to characterize a PEC device

is the solar-to-hydrogen (STH) efficiency performed in a two-electrode cell configuration (i.e., working and counter electrodes) without polarization and under broadband solar irradiance (e.g., Air Mass 1.5 Global Illumination (AM1.5G)) [8].

Still concerning the OER on a photoanode, this reaction is usually considered the kinetic-controlling step for the overall water splitting reaction [12]. In this way, the development of a high-performance photoanode is utterly important for an outstanding PEC water splitting. For a highly efficient water photoelectrooxidation, it is also expected that the photoanode should meet the following requirements: (i) suitable optical  $E_g$  to harvest a wide range of energy from the solar spectrum; (ii) the valence band edge potential ( $E_{VB}$ ) should be more positive than the OER potential (i.e.,  $E_{VB} > 0.83 V_{SHE}$ , pH 7), while the conduction band edge potential ( $E_{CB}$ ) should be more negative than the HER potential (i.e.,  $E_{CB} < -0.40 V_{SHE}$ , pH 7); (iii) high efficient light absorption; (iv) fast and efficient carriers transfer at the photoanode|electrolyte interface; (v) diminished overpotential for the OER; (vi) stable at harsh conditions, such as acid/alkali electrolyte and under polarization and strong sunlight; (vii) the photoanode should not be toxic and be comprised of earth-abundant elements, and (viii) the preparation method for the photoanode should be inexpensive [4,7]. Despite there not yet a photoanode that can abide by all these requirements simultaneously, tungsten trioxide ( $WO_3$ ) seems to meet most of the aforementioned criteria, which makes it a highly promising photoanode for PEC water splitting.

$WO_3$  is naturally an n-type semiconductor featuring a low-cost and non-toxic material with excellent photocatalytic activity on visible light radiation for water photoelectrooxidation applications [13]. Recently, Wang and co-workers have listed several intrinsic optoelectronic properties of  $WO_3$ , which indicates that this is a very attractive material compared to other photoanodes for solar-driven water splitting [4]. Some of the outstanding intrinsic properties of  $WO_3$  photoanodes are: (i) suitable optical indirect  $E_g$  (2.5–2.8 eV [14]), which allows a collection of  $\sim 12\%$  of solar energy for wavelengths  $< 500 \text{ nm}$ ; (ii) high electron mobility ( $\mu_e = 12 \text{ cm}^2 \text{ V}^{-1} \text{ s}^{-1}$ )

and moderate hole diffusion length ( $\sim 150$  nm) when compared to  $\text{TiO}_2$  and  $\alpha\text{-Fe}_2\text{O}_3$  [15,16]; (iii) thermodynamically favourable position of the  $E_{\text{VB}}$  for water oxidation (i.e.,  $E_{\text{VB}}$  is located at ca. 3  $V_{\text{SHE}}$ , which is more positive than the oxidation potential of water (0.83  $V_{\text{SHE}}$ , pH 7)) [17–19], and (iv) high chemical stability in acid medium and resistance to photocorrosion [20]. It is also important to highlight the water photooxidation mechanism on  $\text{WO}_3$  photoelectrode, which is one of the main bottlenecks for the overall light-driven water splitting reaction. So far, very little has been known about the exact molecular reaction mechanism for water photooxidation reaction on  $\text{WO}_3$  photoelectrode. Valdés and Kroes [21] proposed that the reaction mechanism for water photooxidation on  $\text{WO}_3$  surface occurs in four steps as indicated by Eqs. (9)–(12). It was considered pH 0 for these reaction steps.



where \* is the site on top of a surface tungsten atom.

To propose these reaction steps, it was considered that the surface tungsten atoms were completely covered with adsorbed oxygen atoms ( $\text{O}^*$ ), as this is the relevant surface for the photoelectrolysis process. Based on all these steps (see Eqs. (9) to (12)), it is understood that the rate-limiting step for the oxidation process is the one described in Eq. (12), which is the proton transfer from the adsorbed hydroxyl radicals ( $\text{HO}^*$ ) species to the electrolyte [21]. Backing up this information, it was evidenced experimentally by electron detection and spin trapping measurements of the formation of the  $\text{HO}^*$  radicals adsorbed on the surface of  $\text{WO}_3$  aqueous dispersions under illumination [22]. Despite the actual molecular reaction mechanism not yet being fully unfolded, this theoretical study serves as a basis for future studies further understand more complex systems, such as photoelectrochemical water oxidation.

Regarding the physical properties and crystal structure of  $\text{WO}_3$ , this semiconductor is a yellow solid at room temperature that has an  $\text{ABO}_3$  perovskite structure comprised of corner-sharing  $\text{WO}_6$  octahedra ( $A =$  missing element and  $B = \text{W}$ ) [12,23]. However, different syntheses of  $\text{WO}_3$  reveal it with a distorted octahedral structure due to the antiferroelectric displacement of the  $\text{W}$  atoms and mutual rotations of the  $\text{O}$  octahedra [12], allowing the possible phases: tetragonal ( $\alpha\text{-WO}_3$ ), orthorhombic ( $\beta\text{-WO}_3$ ), monoclinic I ( $\gamma\text{-WO}_3$ ), triclinic ( $\delta\text{-WO}_3$ ), monoclinic II ( $\varepsilon\text{-WO}_3$ ), and hexagonal ( $\text{h-WO}_3$ ). Among all the polymorphic  $\text{WO}_3$  crystals, the monoclinic phase I ( $\gamma\text{-WO}_3$ ) is the most stable [14].

$\text{WO}_3$  was obtained for the first time by Robert Oxland in 1841 [24] and the application of  $\text{WO}_3$  films as photoanode for water photoelectrooxidation was first reported by Hodes and co-workers in 1976 [25]. In this work, the authors prepared the  $\text{WO}_3$  films either by annealing the tungsten metal to form the  $\text{W}/\text{WO}_3$  structure or by spraying ammonia tungstate onto a gold-coated glass substrate to obtain the  $\text{glass}/\text{Au}/\text{WO}_3$  structure. Compared with  $\text{TiO}_2$  films, the result of  $\text{W}/\text{WO}_3$  film was very promising, presenting a high applied bias  $\Delta j_{\text{ph}}$  (ca. 1  $\text{mA cm}^{-2}$  at 2.0 V vs. reversible hydrogen electrode (RHE)) and the onset potential ( $E_{\text{on}}$ ) under illumination was shifted 1.4 V towards less positive values compared to the experiment performed in the dark. Despite this initial study presenting very promising results, there are still some limitations that prevent  $\text{WO}_3$  photoanodes to achieve excellent PEC performance for large-scale applications. This is mainly due to the high recombination rate of the electron-hole pair and the slow transfer

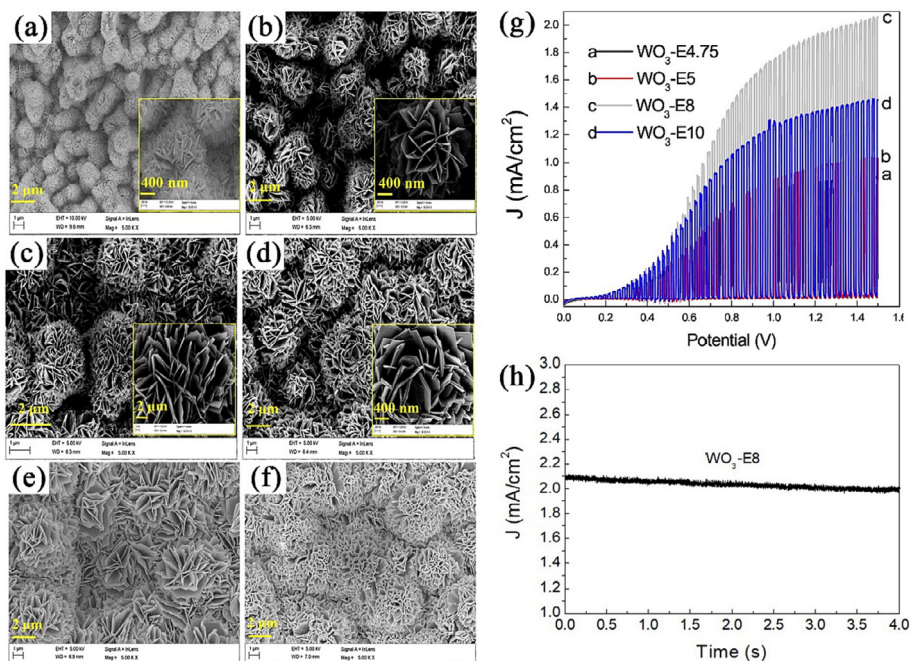
kinetics of the photogenerated holes for water oxidation, leading to a poor and unsatisfactory transfer efficiency of the carriers at the  $\text{WO}_3$ |electrolyte interface [26]. In addition, peroxy species formed on the  $\text{WO}_3$  surface during PEC water splitting can reduce the stability of  $\text{WO}_3$  photoanode due to the photocorrosion process. Another drawback is that the reaction of peroxy species formation can compete with PEC water oxidation [19,27]. Another drawback is that the reported low absorption coefficient ( $\alpha$ ) of  $10^4\text{--}10^5 \text{ cm}^{-1}$  is assigned as the main cause for moderate hole diffusion length [28]. To overcome these issues, Zheng and co-workers [19] reported a variety of strategies to improve the  $\text{WO}_3$  photoelectrocatalytic properties for PEC water splitting. The reported strategies which have recently been systematically classified as design principles [29] include as follow: (i) nanostructured morphology engineering to increase surface area, to minimize electron-hole recombination process, and to facilitate carriers migration towards semiconductor's surface [30]; (ii) photoanode superficial modification with suitable co-catalysts to accelerate PEC water oxidation reaction and to reduce the  $\text{H}_2\text{O}_2$  production [11,31]; (iii) control of the exposed crystal facets at the semiconductor|electrolyte interface to enable facilitation of carriers transfer and high surface reactivity [32,33]; (iv) generation of chemical defects, such as oxygen vacancies, to act as adsorption centers for OH groups and as shallow electron donor [12,34]; (v) employment of doping approach to manipulate optical, electronic properties, and to tailor the electronic band structure of the semiconductor [35]; and (vi) preparation of homo/heterojunctions to allow photogenerated charge carriers to be separated and transported more efficiently [36–38].

All these strategies or also known as design principles have enabled recently considerable growth in the number of publications about  $\text{WO}_3$  photoanodes applied to water photoelectrooxidation. Based on this, the present review aims to show the recent publications concerning the different strategies used to obtain  $\text{WO}_3$  photoanode films for water oxidation. Moreover, we will provide graphic compilations of the published studies and additional comments for future works about how to further improve the photoelectroactivity of  $\text{WO}_3$  photoanodes. To the best of our knowledge, this type of review comes as a novelty for the progress on the  $\text{WO}_3$  photoanodes' studies toward PEC water splitting large-scale application in the future. To help the reader, this review was organized into two main topics, namely bare and modified  $\text{WO}_3$  photoanodes. For these topics, we will present the strategies reported aiming to improve PEC performance and stability for water splitting. These strategies for bare  $\text{WO}_3$  photoanodes were summarized as morphology influence, crystal plane growth control, and defect engineering based on oxygen vacancies; while for modified  $\text{WO}_3$  photoanodes were: doping, surface modification, homojunction, and heterojunction approach. At the end of each section of this review, the main results of the reports discussed were organized in tables for comparative analyses.

## 2. Bare $\text{WO}_3$ photoanodes

### 2.1. Morphology influence

Morphology deals with the study of a material's form, which means the description of its shape, size, and structure [39]. In particular, the morphology of nanomaterials is uniquely important as it can dictate their physical-chemical properties. Different from bulk materials, the morphology of nanostructured materials plays a fundamental role in their photocatalytic activity. In addition to the material being nanostructured or bulky, the thickness of semiconductor materials, as well as the porosity [40], is also crucial for photocatalysis applications. To overcome the low  $\alpha$  of  $\text{WO}_3$ , thicker films were produced, however, bulk materials with thicknesses



**Fig. 2.** (a–f) SEM micrographs and (g) linear sweep voltammograms at 50 mV s<sup>-1</sup> and under chopped solar light simulator (AM1.5G and 100 mW cm<sup>-2</sup>) for the WO<sub>3</sub> films obtained with different hydrothermal reaction times. (h) PEC stability at 1 V<sub>Ag/AgCl</sub> and under solar light simulator for (AM1.5G and 100 mW cm<sup>-2</sup>) for the WO<sub>3</sub>-E8 film. The electrolyte was a solution of 0.1 M Na<sub>2</sub>SO<sub>4</sub>. E4.75, E5, and E10 are the hydrothermal reaction times of 4.75, 5, and 10 h, respectively. Reproduced (adapted) from Ref. [46] with permission from Elsevier, Copyright 2019.

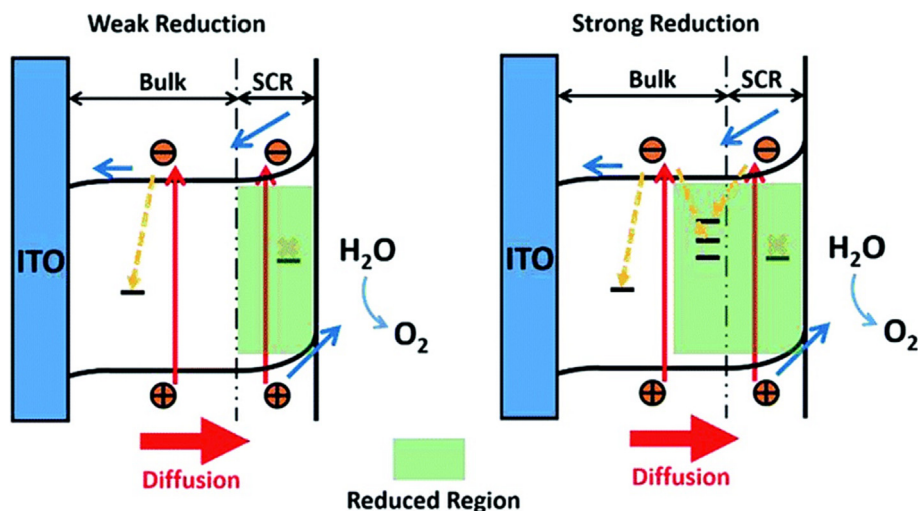
greater than the hole diffusion length imply a higher rate of electron/hole recombination before they can migrate to the semiconductor surface [28,30]. One of the advantages of nanostructured materials is the enlargement of the surface area. For the case of PEC cells, the enlarged surface area of a nanostructured semiconductor film enables more contact with the electrolyte, providing more active sites for carrying out PEC water splitting [41]. Nanostructured materials also show better light absorption due to reducing surface light reflection and increasing light scattering [42]. However, there are several disadvantages associated with the formation of nanostructures, such as a reduction in power conversion efficiency and a decrease in the durability of devices, in addition to many others directly related to PEC systems [43]. In other words, developing a photoelectrode from a given morphology directly influences its photoelectrocatalytic performance and, therefore, a relationship between them must be investigated. In this section, the influence of morphology on the PEC measurements of each system will be discussed based on the WO<sub>3</sub> obtaining methods, such as anodizing [44,45], a hydrothermal method [46–48], sol-gel [49–51], and pulsed laser deposition (PLD) [28,52].

The choice of substrate combined with the deposition method also plays an important role in morphology formation and consequently PEC performance. When it comes to transparent conductive oxides, several materials are used as substrates, such as fluorine-doped tin oxide (FTO), indium-doped tin oxide (ITO), and aluminium-doped zinc oxide (AZO), but only FTO is stable over a wide pH range [53]. Concerning the deposition method, one of the most common approaches for the manufacture of ordered oxide nanostructures is the anodization of metals. Several parameters associated with this method can influence, e.g., the morphology of WO<sub>3</sub>. Zhang and co-workers manufactured nanoporous WO<sub>3</sub> films synthesized by tuning anodization conditions [44]. Parameters such as voltage and temperature of the electrolyte led to substantial morphological changes in the films, as they varied from compact to nanoporous structures that resemble nanotubes. From the optimized condition (anodizing tungsten foils at 40 V and 40 °C

and annealed at 500 °C in O<sub>2</sub> atmosphere), a  $\Delta j_{ph}$  of 1.1 mA cm<sup>-2</sup> at 1.6 V<sub>Ag/AgCl</sub> and IPCE >40% in the UV region were obtained. Roselló-Márquez and co-workers employed the same manufacturing method and optimized the air-treated annealing conditions for the anodized films. The authors obtained WO<sub>3</sub> films featuring nanorods, which delivered a  $\Delta j_{ph}$  of ~0.36 mA cm<sup>-2</sup> at 1 V<sub>Ag/AgCl</sub> for the optimum annealing condition (600 °C in air) [45]. Although the synthesis conditions are similar to the previous study, the difference in photoactivity may be associated with the porous morphology of the obtained films. Porous structures have a larger surface area and a shorter diffusion length for the carriers that can facilitate the ions' transport into the structure and, consequently, improve the photoactivity of the film [54].

It is important to report that by employing the hydrothermal method, different 2D nanostructures were obtained for WO<sub>3</sub> films, such as nanoflowers, nanoflakes, and nanosheets. This difference in morphology allowed the  $\Delta j_{ph}$  to range from 1 to 2 mA cm<sup>-2</sup>. Gu and co-workers prepared nanoflower structured WO<sub>3</sub> thin films (flower cluster diameters were ~1 μm and the petal length was ~200 nm) on Ti substrate with different hydrothermal reaction times (see Fig. 2a–f). This system delivered a  $\Delta j_{ph}$  of 2.0 mA cm<sup>-2</sup> at 1.23 V<sub>Ag/AgCl</sub> and long-term stability of 4 h ( $\Delta j_{ph}$  decayed ~5% from its initial value) for the film obtained with a hydrothermal reaction time of 8 h (labelled as WO<sub>3</sub>-E8), as shown in Fig. 2(g and h), respectively [46]. The authors reported that the nanoflower structure was responsible for the enhanced PEC performance, which was attributed to the surface area enlargement for light absorption, an increase of reaction sites, and provision of more direct transfer channels for photogenerated electrons.

In another study, the control of morphology with the addition of ammonium oxalate ((NH<sub>4</sub>)<sub>2</sub>C<sub>2</sub>O<sub>4</sub>) in the synthesis method was also an important step in the work of Rong and co-workers [48]. The formation of WO<sub>3</sub> nanoflakes-like structure (thickness of 20–30 nm and 2.0 nm for amorphous layer) and the control of its structure parameters such as plate thickness and porosity by the addition of small amounts of (NH<sub>4</sub>)<sub>2</sub>C<sub>2</sub>O<sub>4</sub> enabled the achieving a



**Fig. 3.** Schematic band bending diagram and charge transfer processes in  $\text{WO}_3$  photoanodes after weak and strong reduction treatments. Reproduced from Ref. [28] with permission from the Royal Society of Chemistry, Copyright 2019.

**Table 1**  
Summary of bare  $\text{WO}_3$  photoanodes featuring different morphologies for PEC water splitting.

Material	$\text{WO}_3$ fabrication method	$\text{WO}_3$ morphology	Electrolyte	Illumination	Notable PEC results	Ref.
W/ $\text{WO}_3$	Anodizing	Nanopores	0.5 M $\text{Na}_2\text{SO}_4$	300 W Xe lamp AM1.5G 100 $\text{mW cm}^{-2}$	1.1 $\text{mA cm}^{-2}$ at 1.6 $V_{\text{Ag/AgCl}}$ IPCE > 40% in the UV region	[44]
W/ $\text{WO}_3$	Anodizing	Nanorods	0.1 M $\text{H}_2\text{SO}_4$	AM1.5G 100 $\text{mW cm}^{-2}$	$\sim 0.36 \text{ mA cm}^{-2}$ 1 $V_{\text{Ag/AgCl}}$	[45]
Ti/ $\text{WO}_3$	Hydrothermal	Nanoflowers	0.1 M $\text{Na}_2\text{SO}_4$	300 W Xe lamp AM1.5G 100 $\text{mW cm}^{-2}$	2.0 $\text{mA cm}^{-2}$ 1.23 $V_{\text{Ag/AgCl}}$ IPCE $\sim 40\%$ at 380 nm (1 $V_{\text{Ag/AgCl}}$ ) Stability test for 4 h (decayed $\sim 5\%$ )	[46]
FTO/ $\text{WO}_3$	Hydrothermal	Nanosheets	0.5 M $\text{Na}_2\text{SO}_4$	LED lamp AM1.5G 100 $\text{mW cm}^{-2}$	1.07 $\text{mA cm}^{-2}$ at 1.23 $V_{\text{RHE}}$ IPCE 82% at $\sim 325 \text{ nm}$ (1.23 $V_{\text{RHE}}$ )	[47]
FTO/ $\text{WO}_3$	Hydrothermal	Nanoflakes	0.25 M PBS pH 6.5	Xe lamp AM1.5G 100 $\text{mW cm}^{-2}$	1.8 $\text{mA cm}^{-2}$ at 1.23 $V_{\text{RHE}}$ IPCE $\sim 43\%$ at 330 nm	[48]
FTO/ $\text{WO}_3$	Sol-gel	Porous structures	1 M $\text{H}_2\text{SO}_4$	AM1.5G 100 $\text{mW cm}^{-2}$	2.05 $\text{mA cm}^{-2}$ at 1.23 $V_{\text{RHE}}$ IPCE 74.9% at $\sim 380 \text{ nm}$ Stability test for 10 h (decayed $\sim 79\%$ )	[49]
ITO/ $\text{WO}_3$	Sol-gel	Porous structures	0.5 M $\text{Na}_2\text{SO}_4$	AM1.5G 300 $\text{mW cm}^{-2}$	0.97 $\text{mA cm}^{-2}$ at 1.23 $V_{\text{RHE}}$ IPCE 48.9% at 420 nm Stability test for 1.9 h (decayed 19.1%)	[50]
PtSi/ $\text{WO}_3$	PLD	Columnar grain	0.5 M $\text{H}_2\text{SO}_4$	404 nm laser $\sim 5 \text{ mW}$ output power	29 $\text{mA cm}^{-2}$ at 1.6 $V_{\text{RHE}}$ APCE 7.7% at 404 nm (1.2 $V_{\text{RHE}}$ )	[52]
ITO/ $\text{WO}_3$	PLD	Pyramidal	0.5 M $\text{H}_2\text{SO}_4$	150 W Xe lamp AM1.5G 100 $\text{mW cm}^{-2}$	1.81 $\text{mA cm}^{-2}$ at 1.23 $V_{\text{RHE}}$ $E_{\text{on}} = 0.5 V_{\text{RHE}}$ IPCE, APCE $\sim 95\%$ at 340 nm (1.23 $V_{\text{RHE}}$ )	[28]
ITO/ $\text{N}_2\text{H}_4\text{-WO}_3$	Squeegee method	Nanorods	0.1 M PBS pH 6	500 W Xe lamp 100 $\text{mW cm}^{-2}$	$\sim 0.9 \text{ mA cm}^{-2}$ at 1.23 $V_{\text{RHE}}$ IPCE 43.6% at 420 nm (1.05 $V_{\text{RHE}}$ )	[57]
FTO/ $\text{WO}_3$	Fixed-potential deposition	Not informed	0.1 M $\text{Na}_2\text{SO}_4$	60 W tungsten lamp	$\sim 80\text{--}70 \mu\text{A cm}^{-2}$ at 1 $V_{\text{Ag/AgCl}}$	[58]
p-Si fronted solar cell/ $\text{CoSi}_2/\text{WO}_3$	Co-electrodeposition	Not informed	1 M HCl	AM1.5G	$\sim 0.046 \text{ mA cm}^{-2}$ without bias input	[59]
FTO/ $\text{WO}_3$	Reverse nanoimprint lithography	Nanohole- and nanoline-patterned	PBS pH 7.6 + 1 M $\text{Na}_2\text{SO}_3$	AM1.5G	0.21 $\text{mA cm}^{-2}$ at 1.23 $V_{\text{RHE}}$	[60]

high  $\Delta j_{\text{ph}}$  of  $1.8 \text{ mA cm}^{-2}$  at  $1.23 \text{ V}_{\text{RHE}}$ . On the other side, Zhao and colleagues synthesized a vertically aligned  $\text{WO}_3$  nanosheet array and used electroreduction to form a disordered layer on the  $\text{WO}_3$  surface [47]. This system provided a  $\Delta j_{\text{ph}}$  of  $1.07 \text{ mA cm}^{-2}$  at  $1.23 \text{ V}_{\text{RHE}}$ , and the IPCE has shown a high conversion value, reaching 82% at  $\sim 325 \text{ nm}$ .

Another synthesis method featuring a low cost for the preparation of bare  $\text{WO}_3$  films is the sol-gel methodology, which enables obtaining semiconductor materials with nanoporous structures. Feng and co-workers obtained  $\text{WO}_3$  films presenting the porous structure and small particle sizes with an average width of  $35.4 \text{ nm}$ , and these displayed highly reproducible and excellent photoelectrocatalytic performance for water splitting [49]. The obtained  $\Delta j_{\text{ph}}$  was  $2.05 \text{ mA cm}^{-2}$  at  $1.23 \text{ V}_{\text{RHE}}$ , with an average of  $1.8 \text{ mA cm}^{-2}$  after 50 randomly selected  $\text{WO}_3$  samples and a low standard deviation ( $0.11 \text{ mA cm}^{-2}$ ). Wang and co-workers attributed the formation of  $\text{WO}_3$  nanopore structures as the main factor in improving the PEC  $\text{O}_2$  generation [50]. This structure also provided a more efficient mass transport during the PEC process and the production of more active sites on the surface of the photoelectrode as well as facilitation of the photogenerated carriers transfer. Another interesting aspect to point out is that the carrier dynamics for  $\text{WO}_3$  films featuring porous structures have also been assessed. In this sense, Rodríguez-Pérez et al. [55] deposited porous  $\text{WO}_3$  films with different thicknesses over FTO by screen printing. Concerning the PEC results, the intensity-modulated photocurrent spectroscopy indicated that the rate constant for charge transfer to the electrolyte phase is larger than for the surface recombination process in most of the applied potential range.

PLD has also been used to manufacture efficient and high-quality  $\text{WO}_3$  photoanodes. This method is one of the deposition techniques with greater precision in the mass transfer of material from the target and excellent control of crystallinity and stoichiometry [52,56]. Andrei and co-workers employed PLD to deposit  $\text{WO}_3$  films over Si (001) covered with platinum substrates, and this system proved to be quite stable in acid and alkaline media [52]. Using as a light source a laser diode (wavelength of

$404 \text{ nm}$  and output power of  $\sim 5 \text{ mW}$ ) for the PEC experiments, the  $\text{WO}_3$  with columnar-like morphology showed a  $\Delta j_{\text{ph}}$  of  $29 \text{ mA cm}^{-2}$  at  $1.6 \text{ V}_{\text{RHE}}$  in an acid medium. The authors assigned the PEC high-performance to the improvement of the transfer and the separation rate of the photogenerated carriers that occurred in the (001) 2D columnar ordering structures of the monoclinic  $\text{WO}_3$ .

Cen and co-workers also used PLD to obtain very thin  $\text{WO}_3$  films (thickness of  $500 \text{ nm}$ ) with pyramidal-like morphology. This system enabled improving PEC performance by tuning the depletion region in the  $\text{WO}_3$  films [28]. In terms of  $\Delta j_{\text{ph}}$  response for the OER, the  $\text{WO}_3$  films having an optimized thickness of  $\sim 500 \text{ nm}$  provided a considerable  $\Delta j_{\text{ph}}$  of  $1.81 \text{ mA cm}^{-2}$  at  $1.23 \text{ V}_{\text{RHE}}$ . The authors associated the improved PEC performance to match the width of the depletion region with that of the reduction region (from post-annealing). In reduction regions larger than the depletion region, the sites of recombination eliminate the photogenerated charges (cf. Fig. 3).

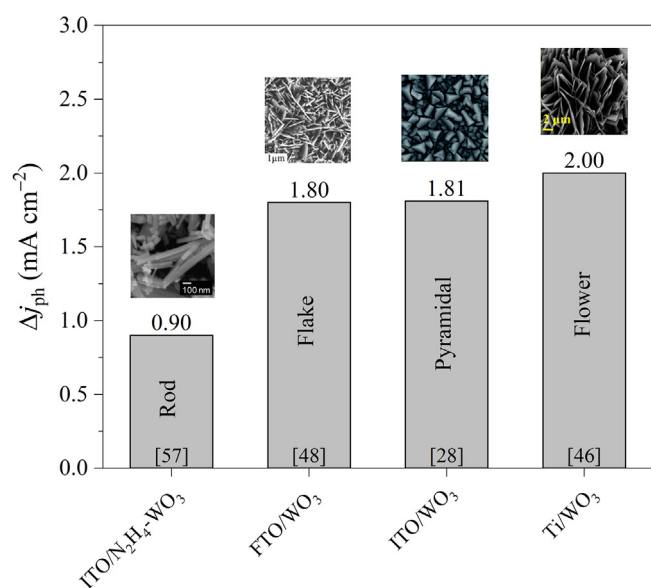
A summary of the most recent studies about the morphology effect on the photoelectroactivity of  $\text{WO}_3$  films is listed in Table 1.

Aiming to compare the photoelectroactivity of the  $\text{WO}_3$  films having different morphologies, some of the data in Table 1 were displayed in Fig. 4 for better visualization of the photoresponse trending. Firstly, it is important to clarify that a fair comparison of the compiled data in Fig. 4 is not possible due to the different electrolytes, substrates, synthesis methods, power of lamps used, and the variability of the surface properties (e.g., surface defects, vacancies, dangling bonds, impurities, etc.) of the  $\text{WO}_3$  films. In this way, the summarized data in Fig. 4 can only provide a general trend, which is still useful as it can provide additional insights on how future works should spend more effort to further improve the PEC response of  $\text{WO}_3$  films for large-scale applications.

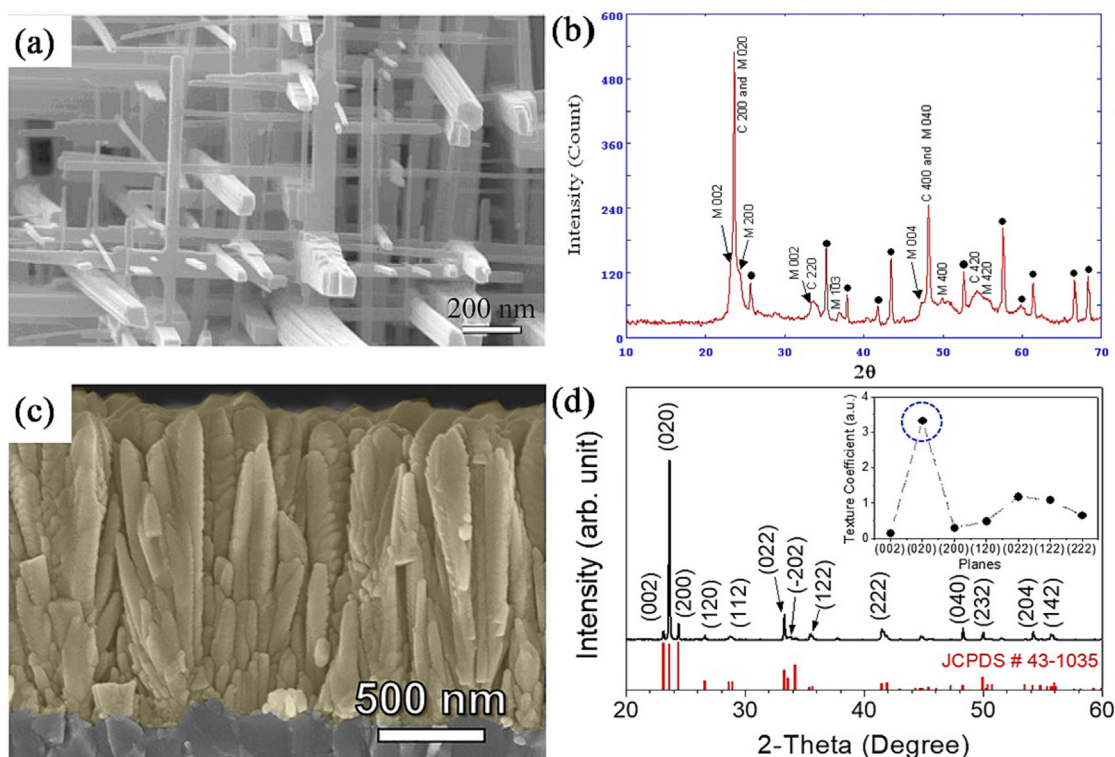
Comparing the  $\Delta j_{\text{ph}}$  values at the standard water oxidation potential ( $1.23 \text{ V}_{\text{RHE}}$ ) for the different  $\text{WO}_3$  morphologies presented in the literature (Fig. 4), one notices that the design of a particular morphology for this photoanode is intrinsically connected to its PEC response for water splitting reaction, and possibly respond to the yield in the  $\text{H}_2$  production rate.  $\text{WO}_3$  nanoflowers [46], pyramidal [28], and nanoflakes [48] morphologies presented the highest  $\Delta j_{\text{ph}}$ , reaching very similar values around  $2.0 \text{ mA cm}^{-2}$ , twice larger than the  $\Delta j_{\text{ph}}$  obtained for the nanorod [57] morphology. These studies show that not only the surface area obtained from the different morphology are responsible for the photoresponse improvement of the  $\text{WO}_3$  films, but also the organization of the nanostructures is revealed to be crucial to increasing the  $\Delta j_{\text{ph}}$ , as highly organized or hierarchical nanostructures lead to high  $\Delta j_{\text{ph}}$ . In other words, obtaining  $\text{WO}_3$  films featuring hierarchical nanostructures, such as nanoflowers, seems to be the best option to achieve a high PEC response for water oxidation. The high photoresponse for such structures is assigned to the combination of enlarged surface area and enhanced light absorption, as hierarchical nanoflowers can increase light absorption by the multiple reflections of the incoming light between the hierarchical nanostructures [61,62]. The nanorod structure can also behave as a light-trapping to increase incident light absorption via the multiple reflections within the nanorods. However, such a phenomenon is only possible for well-aligned and continuous nanorod arrays [63]. Since the reported  $\text{WO}_3$  nanorods were not vertically standing [57], this may have hindered the benefit of light trapping and probably resulted in the relatively low  $\Delta j_{\text{ph}}$  as observed in Fig. 4.

## 2.2. Crystal plane growth control

For the past two years, few studies have reported the use of strategy based on the preferential orientation of  $\text{WO}_3$  crystallographic facets (texturing) applied to water photoelectrooxidation.



**Fig. 4.**  $\Delta j_{\text{ph}}$  values at  $1.23 \text{ V}_{\text{RHE}}$  for  $\text{WO}_3$  photoanodes featuring different morphologies. Reproduced from Refs. [46] with permission from Elsevier, Copyright 2019, [57] with permission from American Chemical Society, Copyright 2019, [48] with permission from Elsevier, Copyright 2020, [28] with permission from Royal Society of Chemistry, Copyright 2019.



**Fig. 5.** (a) Nanowire networks and (c) columnar  $\text{WO}_3$  nanostructure morphologies featuring preferential (020) facets determined from (b) and (d) XRD patterns, respectively. Reproduced from Ref. [66] with permission from Wiley-VCH, Copyright 2005, and Ref. [32] with permission from Elsevier, Copyright 2020.

**Table 2**

Summary of crystal plane control strategy for bare  $\text{WO}_3$  photoanodes.

Material	$\text{WO}_3$ fabrication method	$\text{WO}_3$ morphology	Electrolyte	Illumination	Notable PEC results	Ref.
FTO/(020)-textured $\text{WO}_3$	Laser ablation deposition	Columnar-type	0.5 M PBS pH 7	300 W Xe lamp AM1.5G 100 mW $\text{cm}^{-2}$	3.03 $\text{mA cm}^{-2}$ at 1.23 $V_{\text{RHE}}$ IPCE 87% at 350 nm (1.23 $V_{\text{RHE}}$ ) Stability test for 2 h (decayed ~6%)	[32]
FTO/(002)-textured $\text{WO}_3$	Hydrothermal	Nanoplates	0.1 M $\text{Na}_2\text{SO}_4$	150 W Xe lamp AM1.5G 100 mW $\text{cm}^{-2}$	3.16 $\text{mA cm}^{-2}$ at 1.23 $V_{\text{RHE}}$ IPCE 79% at 400 nm (1.23 $V_{\text{RHE}}$ ) Stability test for 5 h (decayed ~10%)	[33]
FTO/(002)-textured $\text{WO}_3$	Hydrothermal/ Doctor blade coating	Nanoparticles	0.5 M $\text{H}_2\text{SO}_4$	150 W Xe lamp LOT, Germany 100 mW $\text{cm}^{-2}$	3.5 $\text{mA cm}^{-2}$ at 1.23 $V_{\text{RHE}}$ Stability test for 2 h (decayed ~15%)	[67]

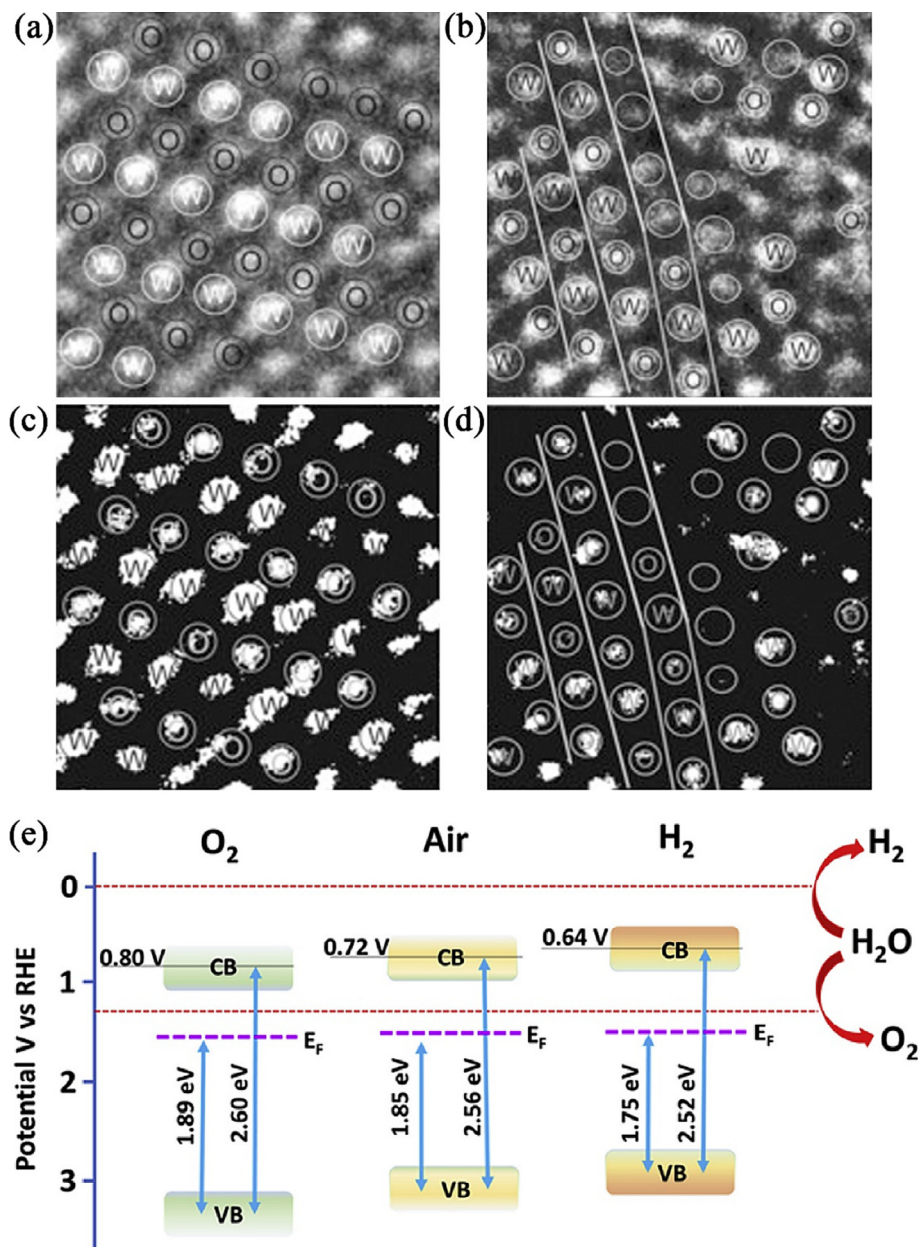
The engineering of  $\text{WO}_3$  crystallographic planes allows achieving improvement of the  $\text{WO}_3$  film photoelectrocatalytic performances due to the exposure of the active facets. For  $\text{WO}_3$  photoanodes, the facet (002) is the one with the highest surface energy ( $1.56 \text{ J m}^{-2}$ ) and is the most favourable one to receive reactive species to reduce on its surface when compared to facets (200) =  $1.43 \text{ J m}^{-2}$  and (020) =  $1.54 \text{ J m}^{-2}$  [64]. Theoretical studies based on density functional theory (DFT) calculations demonstrated that water photooxidation on  $\gamma\text{-WO}_3$  surface demands an overpotential of 1.04, 1.10, and 1.05 V for the faces (200), (020), and (002), respectively [21]. In another theoretical study, Kishore et al. [65] reported that the (200), (020), (002) surfaces of  $\text{WO}_3$  have a negligible effect on the overpotential for OER. The authors also reported that OER can be favoured on  $\text{WO}_3$  surfaces with half coverage of oxygen atoms.

Besides the studies about crystal plane growth control, the occurrence of textured planes combined with the formation of nanostructures offers a large surface area for absorption and permeability of the electrolyte through the nanostructures of  $\text{WO}_3$  films [32,66]. As an example, Fig. 5 shows two different nanostructures for  $\text{WO}_3$  films with (020) facets determined from XRD data.

The combination of such features can potentially further improve the photoelectrocatalytic activity of  $\text{WO}_3$  films for water photoelectrooxidation.

Han and co-workers employed laser ablation deposition to obtain  $\text{WO}_3$  film featuring columnar nanostructures [32] (Fig. 5c). Unlike the acid medium commonly used in experiments involving  $\text{WO}_3$  photoanodes, the authors chose to investigate the performance of the photoelectrode in a neutral medium as an ecological friendly pH conditions strategy. The control of synthesis operational conditions, such as temperature and pressure, allowed obtaining (020)-textured  $\text{WO}_3$  films with a high number of oxygen vacancies. The occurrence of these vacancies leads to an increase in the charge transport in the semiconductor and better transfer efficiencies at the  $\text{WO}_3$ |electrolyte interface. Additionally, the control of the exposed facet combined with the amount of oxygen vacancy allowed the photoelectrode to reach a  $\Delta j_{\text{ph}}$  of  $3.03 \text{ mA cm}^{-2}$  at 1.23  $V_{\text{RHE}}$  and stability of 2 h ( $\Delta j_{\text{ph}}$  retention of 90%) in a neutral medium. In another study, Zheng and co-workers obtained sandwich structure based on (002)-textured  $\text{WO}_3$  films. The facet of greater surface energy, i.e., (002), was grown by hydrothermal method and oriented via agent orientation (citric and tartaric acid) [33].





**Fig. 6.** (a and b) HRTEM and (c and d) HAADF images contrasting pristine  $\text{WO}_3$  with continuous lattice fringes and with oxygen and tungsten deficiency. Reproduced from Ref. [72] with permission from Wiley-VCH, Copyright 2016. (e) Probable band edge positions of  $\text{WO}_3$  photoanodes containing oxygen vacancies introduced via thermal treatment under  $\text{O}_2$ , air, and  $\text{H}_2$  atmospheres. Reproduced from Ref. [78] with permission from Elsevier, Copyright 2019.

**Table 3**  
Summary of defect engineering based on oxygen vacancies approach for bare  $\text{WO}_3$  photoanodes.

Material	$\text{WO}_3$ fabrication method	$\text{WO}_3$ morphology	Electrolyte	Illumination	Notable PEC results	Ref.
FTO/ $\text{WO}_3$ Oxygen vacancies	Hydrothermal	Nanoplates	0.5 M $\text{Na}_2\text{SO}_4$	Xe lamp 100 $\text{mW cm}^{-2}$	1.32 $\text{mA cm}^{-2}$ at 1.23 $V_{\text{RHE}}$ IPCE 70% at 365 nm (1.23 $V_{\text{RHE}}$ )	[76]
W/ $\text{WO}_3$ Oxygen vacancies	Two-step flame heating	Nanoparticles	0.5 M $\text{H}_2\text{SO}_4$	AM1.5G 100 $\text{mW cm}^{-2}$	1.06 $\text{mA cm}^{-2}$ at 1.23 $V_{\text{RHE}}$ $E_{\text{on}} = 0.37 V_{\text{RHE}}$ IPCE 47.9% at 390 nm (1.23 $V_{\text{RHE}}$ ) Stability test for ~1.7 h (approx. const.)	[77]
FTO/ $\text{WO}_3$ Oxygen vacancies	Hydrothermal	Nanopores and blocks	0.1 M $\text{Na}_2\text{SO}_4$	1000 W Xe lamp AM1.5G 100 $\text{mW cm}^{-2}$	3.33 $\text{mA cm}^{-2}$ at 2 $V_{\text{RHE}}$ IPCE ~50% at 400 nm (1.23 $V_{\text{RHE}}$ ) Stability test for 4 h (decayed 20%)	[78]
W/ $\text{WO}_3$ Oxygen vacancies	Hydrothermal	Nanoplates	0.5 M $\text{Na}_2\text{SO}_4$	300 W Xe lamp AM1.5G 100 $\text{mW cm}^{-2}$	4.12 $\text{mA cm}^{-2}$ at 1.6 $V_{\text{Ag}/\text{AgCl}}$ $E_{\text{on}} = 0.22 V_{\text{Ag}/\text{AgCl}}$ IPCE ~56.22% at 300 nm Stability test for 1 h (decayed ~5%)	[79]

The authors achieved a  $\Delta j_{\text{ph}}$  of  $3.16 \text{ mA cm}^{-2}$  at  $1.23 \text{ V}_{\text{RHE}}$  and stability up to 5 h ( $\Delta j_{\text{ph}}$  decayed  $\sim 10\%$  from its initial value), which is so far one of the most notable results for pristine  $\text{WO}_3$  films being no superficially modified or doped. According to the authors, both the preferred orientation of the (002) plane and the formation of  $\text{WO}_3$  nanoplates contributed to the outstanding performance of the photoelectrode. Furthermore, the number of carboxylic groups of organic acids allowed for adequate texturing while the synergistic effect of the highly reactive exposed facet (002) and the 2D nanostructure facilitated the separation of photogenerated electron-hole pairs and suppressed the formation of peroxo-species [33].

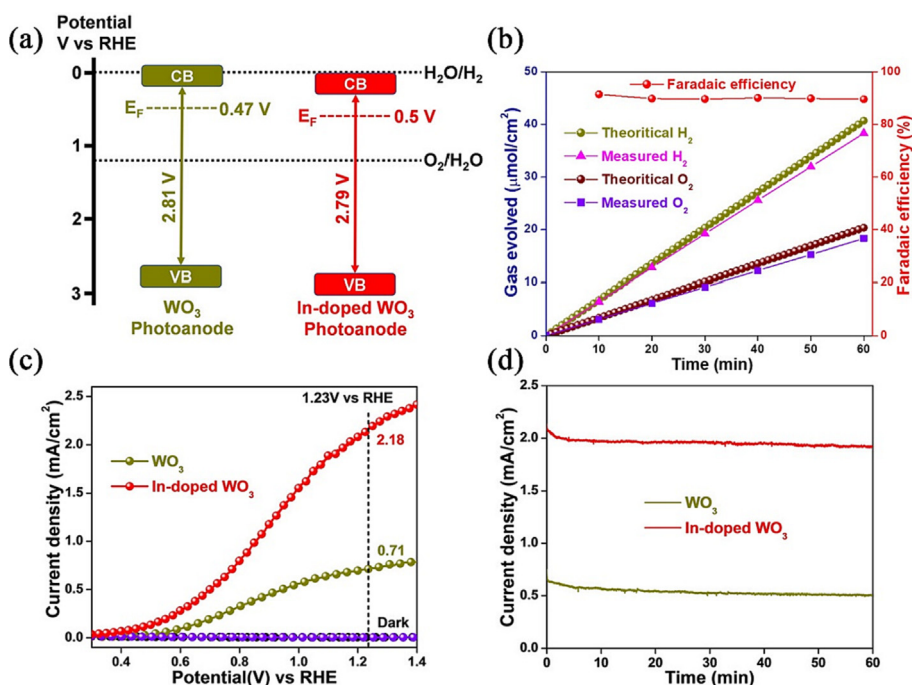
In summary, these studies (listed in Table 2) show the possibility of obtaining highly efficient  $\text{WO}_3$  films for PEC oxidation of water by simply controlling the texturing of planes. The facile and green hydrothermal method used by Zheng and co-workers [33] proved to be efficient and a step forward in the engineering of materials for energy conversion in PEC cells.

### 2.3. Defect engineering based on oxygen vacancies

The engineering of chemical defects in semiconductor materials is also considered an excellent strategy for boosting water splitting in PEC cells. Differently from physical defects (such as cracks and micro-sized holes) inside the semiconductor that could negatively interfere with the photocatalytic activity, chemical defects, such as oxygen vacancies, can contribute positively to the PEC activity of  $\text{WO}_3$  films [68]. Such vacancies can act as adsorption centres for OH groups as well as shallow electron donors which are positive effects to promote an improvement in the PEC activity [12,34]. In addition, the DFT approach has shown strong dependence on the OER overpotential with the presence of oxygen vacancies and doping effect [65]. This dependency is economically attractive as the input energy, i.e., applied potential, used in the PEC water splitting can be minimized or compensated for the presence of a number of oxygen vacancies.

Recently, some strategies have been used to induce oxygen vacancies in semiconductor oxides, such as Ar-plasma-etched [69], radiofrequency hydrogen plasma [70], vacuum heat treatment [71], reducing reagents [72], thermal treatment in  $\text{H}_2$  atmosphere [73], electrochemical reduction [74], and flame reduction [75]. Another way to induce the formation of oxygen vacancies is via a solution-based reducing agent, namely lithium dissolved in ethylenediamine [72]. Employing this approach and using high-resolution transmission electron microscopy (HRTEM) (Fig. 6a and b) and high-angle annular dark-field (HAADF) techniques (Fig. 6c and d), Ma and co-workers [72] were able to show the pristine  $\text{WO}_3$  with continuous lattice fringes and with oxygen and tungsten deficiencies. In Table 3, it can be seen that studies in which oxygen vacancies were introduced by Ar plasma [76] and flame heating approach [77] enabled achieving  $\Delta j_{\text{ph}}$  of approximately  $1.32 \text{ mA cm}^{-2}$  and  $1.06 \text{ mA cm}^{-2}$  at  $1.23 \text{ V}_{\text{RHE}}$ , respectively.

In some other studies, an even higher photocatalytic performance was observed for  $\text{WO}_3$  films in which oxygen vacancies were introduced by air annealing after hydrothermal treatment [78,79]. In this regard, Kalanur and co-workers reported that increasing the number of oxygen vacancies led to a decrease in the optical  $E_g$ , an increase in the density of carriers, and a significant upward shifting of the band edge positions (see Fig. 6e) [78]. This allowed the system to have a wider light-harvesting in the visible and infrared regions and more efficient charge transportation upon illumination. In terms of photoresponse, the photoanode showed a  $\Delta j_{\text{ph}}$  of  $3.33 \text{ mA cm}^{-2}$  at  $2 \text{ V}_{\text{RHE}}$  and long-term stability of 4 h ( $\Delta j_{\text{ph}}$  maintained 80% of its initial value). In another study, Soltani and co-workers employed a metallic tungsten substrate to manufacture  $\text{WO}_3$  films having dual oxygen and tungsten vacancies [79]. The prepared  $\text{WO}_3$  films featured porous and uniform distribution of nanoplate structures that rendered a large surface area, which the authors attributed to being the one responsible for the efficient charge collecting capability. Additionally, not only the oxygen vacancies, but also its maximum number of  $\text{W}^{5+}$  states led to several improvements in the system, such as



**Fig. 7.** (a) Position band edge potentials for bare  $\text{WO}_3$  and In-doped  $\text{WO}_3$  films, (b) Faradaic efficiency plot for In-doped  $\text{WO}_3$  films, (c) linear sweep voltammograms at  $10 \text{ mV s}^{-1}$  in the dark and under solar light simulator ( $\text{AM1.5G}$  and  $100 \text{ mW cm}^{-2}$ ), and (d) PEC stability at  $1.23 \text{ V}_{\text{RHE}}$  and under solar light simulator ( $\text{AM1.5G}$  and  $100 \text{ mW cm}^{-2}$ ) for bare  $\text{WO}_3$  and In-doped  $\text{WO}_3$  films. The electrolyte was an  $\text{N}_2$ -saturated solution of  $0.1 \text{ M Na}_2\text{SO}_4$  at pH 6.0. Reproduced (adapted) from Ref. [85] with permission from Wiley-VCH, Copyright 2020.

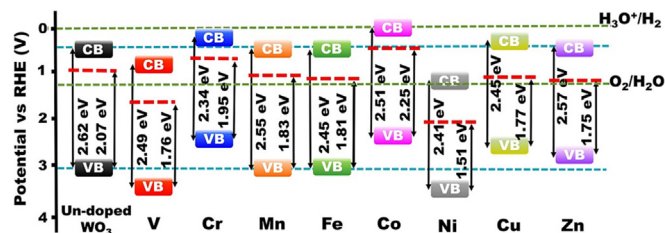


Fig. 8. Position band edge potentials for  $\text{WO}_3$  films not doped and doped with different metals. Reproduced from Ref. [86] with permission from Elsevier, Copyright 2020.

the decrease in the charge carrier resistances at the  $\text{WO}_3$ |electrolyte interface, an increase in the charge carrier concentration, and minimization the photogenerated electron-hole recombination. These improvements allowed the  $\text{WO}_3$  films to reach a  $\Delta j_{\text{ph}}$  of  $4.12 \text{ mA cm}^{-2}$  at  $1.6 \text{ V}_{\text{Ag}/\text{AgCl}}$  and stability of 1 h (the  $\Delta j_{\text{ph}}$  decayed 9% from its initial value).

### 3. Modified $\text{WO}_3$ photoanodes

#### 3.1. Doping

Doping a semiconductor with metallic/non-metallic elements is a strategy used to manipulate its optical and electronic properties, and tailor its band structure [4,35]. In other words, doping can provide for a semiconductor: extension of the light range absorption, enhancement of the electronic transport capability, and desirable modification of the band edge positions [4]. For semiconductors having wide optical  $E_g$  energy, doping can also be used to narrow the separation between the energy bands, as in the case of, e.g.,  $\text{TiO}_2$  [80]; for semiconductors that are characterized by low electrical conductivity, such as  $\text{Fe}_2\text{O}_3$ , doping can increase the concentration of charge carriers and accelerate the kinetics of the oxidation reaction [81,82]; or even shift the maximum of the valence band and the minimum of the conduction band [83]. In addition, the doping of  $\text{WO}_3$  films with isovalent elements normally limits the formation of defects such as vacancy due to the compatibility of the charges, while the doping with non-isovalent elements is generally compensated by the formation of oxygen vacancies [83,84].

Regarding the doping studies of  $\text{WO}_3$  films for PEC water splitting application, it is reported a variety of doping elements, including In [85], first-row transition metal [86], and alkali ions [87]. Mohanta and co-workers reported that  $\text{W}^{6+}$  ions in the  $\text{WO}_3$  struc-

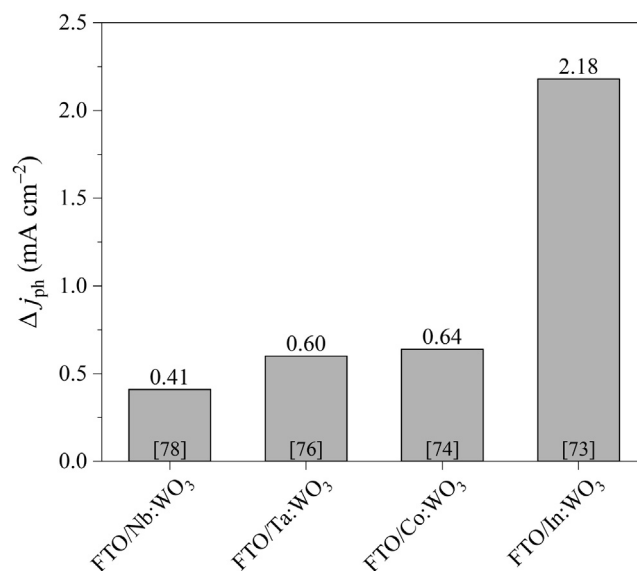


Fig. 9.  $\Delta j_{\text{ph}}$  values at  $1.23 \text{ V}_{\text{RHE}}$  for Nb-, Ta-, Co-, and In-doped  $\text{WO}_3$  photoanodes.

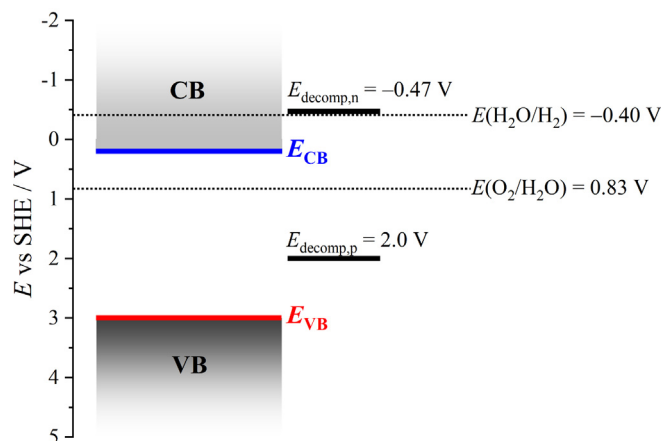
ture were partially occupied by  $\text{In}^{3+}$  ions in the In: $\text{WO}_3$  system [85]. The authors achieved a significant increase in the density of charge carriers, which was three-fold greater than the undoped  $\text{WO}_3$ , and downward shifting of the CB and VB (see Fig. 7a). As a result, the  $\eta_F$  reached  $\sim 90\%$  for PEC water oxidation (cf. Fig. 7b), allowing a  $\Delta j_{\text{ph}}$  of  $2.18 \text{ mA cm}^{-2}$  at  $1.23 \text{ V}_{\text{RHE}}$  and stability of 1 h (decayed  $\sim 5\%$  from its initial value), as shown in Fig. 7(c and d), respectively.

Klamur and co-workers reported a systematic protocol for doping  $\text{WO}_3$  films with a first-row transition metal (V, Cr, Mn, Fe, Co, Ni, Cu, and Zn). This study focused on the band edge engineering of  $\text{WO}_3$  films to reduce the energy of  $E_g$  and alter band edge location (see Fig. 8) [86]. It was reported that the type of dopant directly influenced several properties of the  $\text{WO}_3$  films, such as the crystalline phase, the density of the charge carrier, and the formation of oxygen vacancies. In contrast to the doping with V and Cr which decreased the PEC performance, all the other dopants promoted an improvement of the photoelectroactivity, especially the Co: $\text{WO}_3$  films, which presented the best  $\Delta j_{\text{ph}}$  of  $\sim 0.64 \text{ mA cm}^{-2}$  at  $1.23 \text{ V}_{\text{RHE}}$  and IPCE of 62.9% at 300 nm. Doping with Co resulted

Table 4

Summary of dopant elements employed for bare  $\text{WO}_3$  photoanodes.

Material	$\text{WO}_3$ fabrication method	$\text{WO}_3$ morphology	Electrolyte	Illumination	Notable PEC results	Ref.
FTO/In: $\text{WO}_3$	Hydrothermal	Nanoblocks	0.1 M $\text{Na}_2\text{SO}_4$	AM1.5G 100 $\text{mW cm}^{-2}$	$2.18 \text{ mA cm}^{-2}$ at $1.23 \text{ V}_{\text{RHE}}$ IPCE 42% at 373.7 nm ( $1.23 \text{ V}_{\text{RHE}}$ ) $E_{\text{on}} = 0.5 \text{ V}_{\text{RHE}}$ Stability test for 1 h (decayed $\sim 5\%$ )	[85]
FTO/Co: $\text{WO}_3$	Hydrothermal	Nanorods and nanoparticles	0.5 M $\text{Na}_2\text{SO}_4$	1000 W Xe lamp AM1.5G	$\sim 0.64 \text{ mA cm}^{-2}$ at $1.23 \text{ V}_{\text{RHE}}$ IPCE 62.93% at 300 nm ( $1.23 \text{ V}_{\text{RHE}}$ )	[86]
FTO/Li: $\text{WO}_3$	Doctor blade method	Spherical nanoparticles	0.2 M $\text{Na}_2\text{SO}_4$	500/150 W Xe lamp AM1.5G 100 $\text{mW cm}^{-2}$	$0.43 \text{ mA cm}^{-2}$ at $0.65 \text{ V}_{\text{Ag}/\text{AgCl}}$ IPCE 28% at 320 nm	[87]
FTO/Ta: $\text{WO}_3$	Hydrothermal	Nanotriangles	0.5 M $\text{Na}_2\text{SO}_4$	1000 W Xe lamp AM1.5G 100 $\text{mW cm}^{-2}$	$\sim 0.60 \text{ mA cm}^{-2}$ at $1.23 \text{ V}_{\text{RHE}}$ IPCE $\sim 58\%$ at 300 nm ( $1.23 \text{ V}_{\text{RHE}}$ )	[88]
FTO/Sn: $\text{WO}_3$	Hydrothermal	Nanoparticles and plates	0.5 M $\text{Na}_2\text{SO}_4$	1000 W Xe lamp AM1.5G	$\sim 0.43 \text{ mA cm}^{-2}$ at $1.23 \text{ V}_{\text{RHE}}$ IPCE 44% at 300 nm ( $1.23 \text{ V}_{\text{RHE}}$ ) Stability test for 2.3 h (decayed $\sim 5\%$ )	[89]
FTO/Nb: $\text{WO}_3$	Hydrothermal	Nanotriangles	0.5 M $\text{Na}_2\text{SO}_4$	1000 W Xe lamp AM1.5G 100 $\text{mW cm}^{-2}$	$\sim 0.41 \text{ mA cm}^{-2}$ at $1.23 \text{ V}_{\text{RHE}}$ IPCE 52% at 300 nm ( $1.23 \text{ V}_{\text{RHE}}$ ) Stability test for 3 h (decayed $\sim 8\%$ )	[90]
FTO/Cu: $\text{WO}_3$	Hydrothermal	Microsheets	0.5 M $\text{Na}_2\text{SO}_4$	Xe lamp AM1.5G 100 $\text{mW cm}^{-2}$	$2.8 \text{ mA cm}^{-2}$ at $1.23 \text{ V}_{\text{RHE}}$ IPCE $\sim 35\%$ at 340 nm ( $1.23 \text{ V}_{\text{RHE}}$ ) ABPE 0.27% at $1.0 \text{ V}_{\text{RHE}}$ Stability test for 2 h (decayed $\sim 15\%$ )	[91]



**Fig. 10.** Band edge potentials positions and decomposition potentials for  $\text{WO}_3$  in a generic neutral pH medium.  $E_{\text{decomp,n}}$  is the  $\text{WO}_3$ 's decomposition potential for reduction by electrons,  $E(\text{H}_2\text{O}/\text{H}_2)$  and  $E(\text{O}_2/\text{H}_2\text{O})$  are the potentials for the cathodic and anodic decomposition of water, respectively. Adapted from Ref. [95].

in an upward shifting of the band edge positions, leading to a more suitable position for water oxidation. Additionally, the  $E_{\text{on}}$  was shifted to less positive values, which enabled to reduce the overpotential required for water oxidation. There was also a reduction in the  $E_g$  from 2.62 to 2.52 eV compared to the undoped  $\text{WO}_3$  film. All these factors contributed to the Co doping being the best dopant among the others in the photocatalytic activity of  $\text{WO}_3$  films.

In addition to the transition metal dopants, Yin and co-workers doped the  $\text{WO}_3$  films with alkali ions by employing (Li, Na, or  $\text{K}$ ) $_2\text{SO}_4$ -based electrolyte [87]. According to the authors, the Li:  $\text{WO}_3$  films provided the best PEC performance compared to the other alkali dopants (0.43, 0.35, and 0.37  $\text{mA cm}^{-2}$  at 0.65  $V_{\text{Ag}/\text{AgCl}}$  for Li-, Na-, and K-doped  $\text{WO}_3$ , respectively). This was due to the reduced radius of  $\text{Li}^+$  ions that facilitated their insertion into the  $\text{WO}_3$  lattice and provided the best PEC performance among these dopants.

Another system being studied is the Ta-doped  $\text{WO}_3$  which resulted in shifting the band edge positions and reduction of the optical  $E_g$  energy compared to the undoped  $\text{WO}_3$  films. Additionally, there was an increase in the density of the carrier and the number of oxygen vacancies [88]. Other systems, such as Sn [89] and Nb-doped [90]  $\text{WO}_3$  have also produced similar effects, mainly by inducing downward shifting of the VB and CB as well as changes in the morphology and crystallographic orientation. Compared to the Sn and Nb dopants, Ta dopant enabled a partial or total change in the crystallographic phase of  $\text{WO}_3$  films (from monoclinic/orthorhombic to hexagonal phase) due to the process of reconstructive transformation during annealing. The Ta:  $\text{WO}_3$  system was also the one that provided the best PEC result ( $\sim 0.60 \text{ mA cm}^{-2}$  at 1.23  $V_{\text{RHE}}$ ), possibly associated with a combination of factors, such as charge carrier density higher than Sn:  $\text{WO}_3$  and Nb:  $\text{WO}_3$  films and low optical  $E_g$  value. A summary of the most recent studies about doping  $\text{WO}_3$  films for PEC water splitting are listed in Table 4.

Seeking to observe a general trend of the  $\text{WO}_3$  films photoreponse, Fig. 9 presents the  $\Delta j_{\text{ph}}$  reported in the literature at the standard water oxidation potential (1.23  $V_{\text{RHE}}$ ) for  $\text{WO}_3$  photoanode doping with different metals. As already mentioned, the compilation of PEC data in Fig. 9 serves only to observe a possible trend and there is no intention to systematically compare these data due to the differences in surface characteristics, materials crystallinity and so forth. As shown in Fig. 9, the doping of  $\text{WO}_3$  with In [85] was the most successful option reported in the literature, reaching

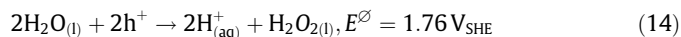
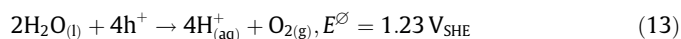
at least three times higher  $\Delta j_{\text{ph}}$  compared to the doping with Nb [90], Ta [88], or Co [86]. The insertion of 3% of  $\text{In}^{3+}$  in place of  $\text{W}^{6+}$  added additional charge carriers, amplifying the number of carriers' density in the photoanode. Based on these results, the enhancement of the photoelectroactivity of  $\text{WO}_3$  photoanodes via doping with a well-chosen metal seems to be a more effective approach compared to the control of morphology, as can be observed comparing the results presented in Fig. 4 and 9. Although it may be a challenge, the combination of doping and the design of hierarchical nanostructures could be an alternative way to greatly improve the photoelectroactivity of the  $\text{WO}_3$  photoanodes for water splitting.

### 3.2. Surface modification

For a large-scale application of PEC technology, several parameters must be dealt with equal importance to produce an efficient and viable device. Some of these parameters include cost-effective materials and techniques, photochemical performance, and stability [92].

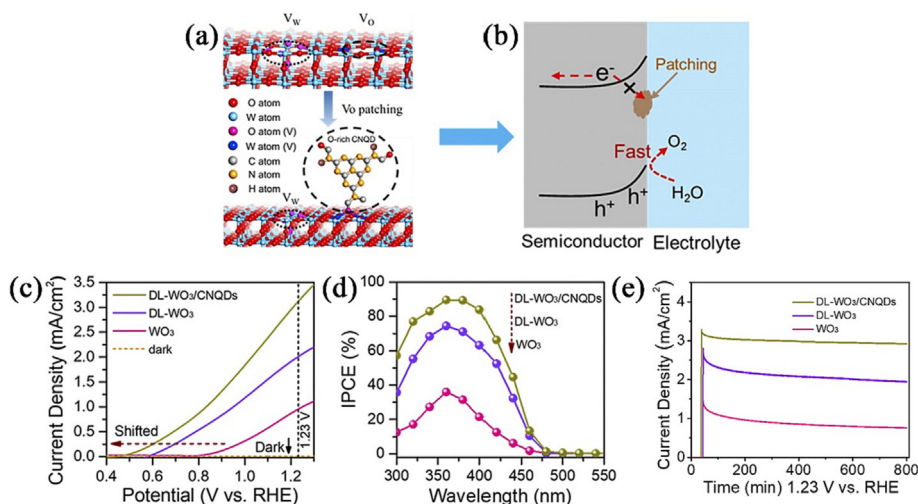
The chemical instability of a photoelectrode, particularly, is one of the key points that can cause a device to become inefficient or inoperable at PEC *operando* conditions. Among the main metal oxides used as photoanodes,  $\text{WO}_3$ ,  $\text{ZnO}$ , and  $\text{Fe}_2\text{O}_3$  are the ones that present the most critical issues that directly affect their stability during the solar-driven water splitting process [93]. For  $\text{WO}_3$  in particular, although this material is prone to anodic photodecomposition due to its decomposition potential for oxidation by holes ( $E_{\text{decomp,p}}$ ) is less positive than its  $E_{\text{VB}}$  (cf. Fig. 10), such process is hindered as a result of  $\text{WO}_3$  being metastable, i.e.,  $\text{WO}_3$  is protected by the thermodynamically preferred decomposition of the electrolyte/solvent [94]. In other words, since the potential for anodic decomposition of the solvent, namely water oxidation, is less positive than the  $E_{\text{decomp,p}}$  for  $\text{WO}_3$  (see Fig. 10), the photooxidation of water on  $\text{WO}_3$  occurs preferentially, which prevents triggering the anodic photodecomposition process of the  $\text{WO}_3$  crystal [95].

Despite the  $\text{WO}_3$  photoanodes being thermodynamically metastable against photocorrosion, it is important to mention that some factors still contribute to the  $\text{WO}_3$  undergoing losses of its photoactivity during long-term stability. Wang and co-workers have listed two of the main causes of such losses [4,27,96]: (i)  $\text{WO}_3$  can participate in an acid-base reaction due to its Arrhenius acid behaviour in an aqueous medium; and (ii) production of peroxo species during the oxidation of water, which can accumulate on the surface of the  $\text{WO}_3$  photoanode and compromise its photocatalytic activity, i.e., slowing down the water oxidation kinetics. Thermodynamically, the OER via water oxidation process (cf. Eq. (13)) is more attainable than the formation of peroxo species (see Eq. (14)) [27,97].



However, the slow kinetics of the OER can lead to the formation of peroxo species, which seems to kinetically compete with  $\text{O}_2$  evolution [11,31]. This issue can be addressed by modifying the surface of  $\text{WO}_3$  photoelectrodes with suitable oxygen evolution co-catalysts (OEC) to improve the kinetics of the OER. As a result, the presence of an OEC can suppress the formation of peroxo species, leading to an increase in the photostability of  $\text{WO}_3$  as well as improvement of PEC  $\text{O}_2$  generation.

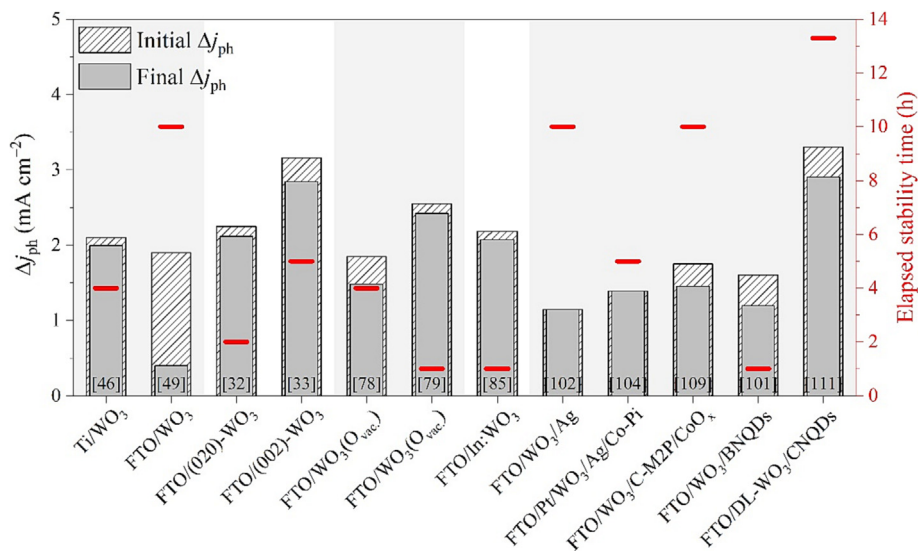
Recently, several types of co-catalysts have been used to modify the surface of  $\text{WO}_3$  photoelectrodes, such as nanoparticles of noble metals [98,99], oxides [100], and quantum dots [101]. Li and co-workers prepared  $\text{WO}_3$  films decorated with Ag nanoparticles pre-



**Fig. 11.** (a) Schematic representation of the possible patching process of the surface DL ( $V_w$  and  $V_o$  are the W and O vacancy sites, respectively; O atom (V) and W atom (V) are the O atoms and W atoms around the vacancy). (b) Defect "patching" by non-passivating oxygen-rich CNQDs. The defect "patching" allows photo-induced holes to move towards the photoanode/electrolyte interface to directly oxidize water. (c) Linear sweep voltammograms in the dark and under solar light simulator (AM1.5G), (d) IPCE plots, and (e) PEC stability at  $1.23 V_{RHE}$  and under solar light simulator (AM1.5G) for  $WO_3$ , DL- $WO_3$ , and DL- $WO_3$ /CNQDs films. The electrolyte was a solution of 0.5 M  $Na_2SO_4$ . Reproduced (adapted) from Ref. [111] with permission from Elsevier, Copyright 2019.

**Table 5**  
Summary of surface modification approaches for  $WO_3$  photoanodes.

Material	$WO_3$ fabrication method	$WO_3$ morphology	Electrolyte	Illumination	Notable PEC results	Ref.
FTO/ $WO_3$ /Ag	Solvothermal	Nanosheets	0.2 M $Na_2SO_4$	Xe lamp 100 $mW cm^{-2}$	1.15 $mA cm^{-2}$ at 1.23 $V_{RHE}$ ABPE 0.09% at $\sim 1.1 V_{RHE}$ IPCE 57.8% at 330 nm Stability test for 10 h (approx. const.)	[102]
FTO/ $WO_3$ /Au	Solvothermal	Nanoflakes	0.5 M $Na_2SO_3$	300 W Xe lamp	1.01 $mA cm^{-2}$ at 1.23 $V_{RHE}$ IPCE $\sim 45\%$ at 300–470 nm	[98]
FTO/ $WO_3$ /Au	Hydrothermal	Plates	0.5 M $Na_2SO_4$	150 W Xe lamp AM1.5G 100 $mW cm^{-2}$	0.78 $mA cm^{-2}$ at 1 $V_{Ag/AgCl}$ IPCE 57% at 300–400 nm	[103]
FTO/Pt/ $WO_3$ /Ag/Co-Pi	Hydrothermal	Smooth-faced nanorods	0.2 M $Na_2SO_4$	300 W Xe lamp AM1.5G 100 $mW cm^{-2}$	1.39 $mA cm^{-2}$ at 1.23 $V_{RHE}$ IPCE 40.8% at 380 nm Stability test for 5 h (approx. const.)	[104]
FTO/ $WO_3$ /PdO	Chemical vapor deposition	Nanoneedles	0.1 M $H_2SO_4$	AM1.5G 100 $mW cm^{-2}$	0.28 $mA cm^{-2}$ at 1.23 $V_{RHE}$ $E_{on} = 0.55 V_{RHE}$ IPCE 49% at 325 nm (1.23 $V_{RHE}$ ) Stability test for 4 h (decayed $\sim 12.5\%$ )	[100]
FTO/ $WO_3$ /CoFe <sub>2</sub> O <sub>4</sub>	Hydrothermal	Nanoplates	0.1 M $Na_2SO_4$	AM1.5G	$\sim 0.035 mA cm^{-2}$ at 1.23 $V_{RHE}$ $E_{on} = 0.1 V_{Ag/AgCl}$	[110]
FTO/ $WO_3$ /C-M2P/CoO <sub>x</sub>	Hydrothermal	Nanosheets	0.1 M $Na_2SO_4$	LED 400 nm AM1.5G	3.5 $mA cm^{-2}$ at 1.23 $V_{NHE}$ IPCE 71% at 400 nm (1.23 $V_{NHE}$ ) ABPE 0.71% at 1.05 $V_{RHE}$ Stability test for 10 h (decayed $\sim 17\%$ )	[109]
FTO/ $WO_3$ /Mössbauerite	Hydrothermal	Nanoporous plate	0.1 M $Na_2SO_4$ + PBS	AM1.5G 100 $mW cm^{-2}$	1.22 $mA cm^{-2}$ at 1.23 $V_{RHE}$	[113]
FTO/ $WO_3$ /BNQDs	Hydrothermal	Nanoblocks	0.1 M $Na_2SO_4$	250 W W lamp 100 $mW cm^{-2}$	1.63 $mA cm^{-2}$ at 1.23 $V_{RHE}$ IPCE 32% at 350–400 nm Stability test for 1 h (decayed $\sim 25\%$ )	[101]
FTO/ $WO_3$ /N:CDs	Hydrothermal	Nanoflakes	1 M $H_2SO_4$	500 W Xe lamp AM1.5G 100 $mW cm^{-2}$	1.42 $mA cm^{-2}$ at 1 $V_{SCE}$ IPCE 97% at 380 nm	[112]
FTO/DL- $WO_3$ /CNQDs	Drop coating method	Nanopores	0.5 M $Na_2SO_4$	AM1.5G	3.1 $mA cm^{-2}$ at 1.23 $V_{RHE}$ $E_{on} = 0.5 V_{RHE}$ IPCE $\sim 90\%$ at 350–400 nm (1.23 $V_{RHE}$ ) Stability test for $\sim 13.3$ h (decayed $\sim 12\%$ )	[111]
FTO/ $WO_3$ /Fh <sup>a</sup> ( <sup>a</sup> Fh: Ferrihydrite)	Hydrothermal	Plate-like	0.5 M $Na_2SO_4$ pH 6.8	300 W Xe lamp AM1.5G 100 $mW cm^{-2}$	0.61 $mA cm^{-2}$ at 1.23 $V_{RHE}$ ABPE 0.066% at 1.05 $V_{RHE}$ IPCE 20.7% at 350 nm (1.23 $V_{RHE}$ ) Stability test for 0.5 h (decayed $\sim 15\%$ )	[114]



**Fig. 12.** Elapsed stability time and initial and final  $\Delta j_{ph}$  values were achieved before and after the stability test, respectively, at 1.23  $V_{RHE}$  for the  $WO_3$  photoanodes featuring the most recent modification strategies reported in the literature. The presented values of  $\Delta j_{ph}$  correspond to approximations based on the elapsed stability tests from their initial and final values.

pared by in situ cathodic reduction [102]. The presence of Ag nanoparticles enabled enhancing the separation of charges on the surface and improving the photoanode performance, which reached a  $\Delta j_{ph}$  of 1.15  $\text{mA cm}^{-2}$  at 1.23  $V_{RHE}$ . In addition, long-term photostability showed remarkable durability, remaining quite stable for 10 h under constant illumination. The presence of Au nanoparticles on  $WO_3$  films has also shown interesting results, not only in the improvement of light-harvesting efficiency due to the effect of surface plasmonic resonance (SPR) but also in the charge separation at the interface [98,103]. Li and co-workers combined the SPR effect with the catalytic property of an OEC via superficial modification of the  $WO_3$  films with Ag nanoparticles and an amorphous layer of cobalt phosphate (Co-Pi), respectively [104]. The Ag nanoparticles played a role in accelerating charge separation, while Co-Pi behaved facilitating the transfer of photo-generated holes to oxidize water into  $O_2$ . As a result, this system achieved a  $\Delta j_{ph}$  of 1.39  $\text{mA cm}^{-2}$  at 1.23  $V_{RHE}$  and improved photostability of 5 h during the experiment.

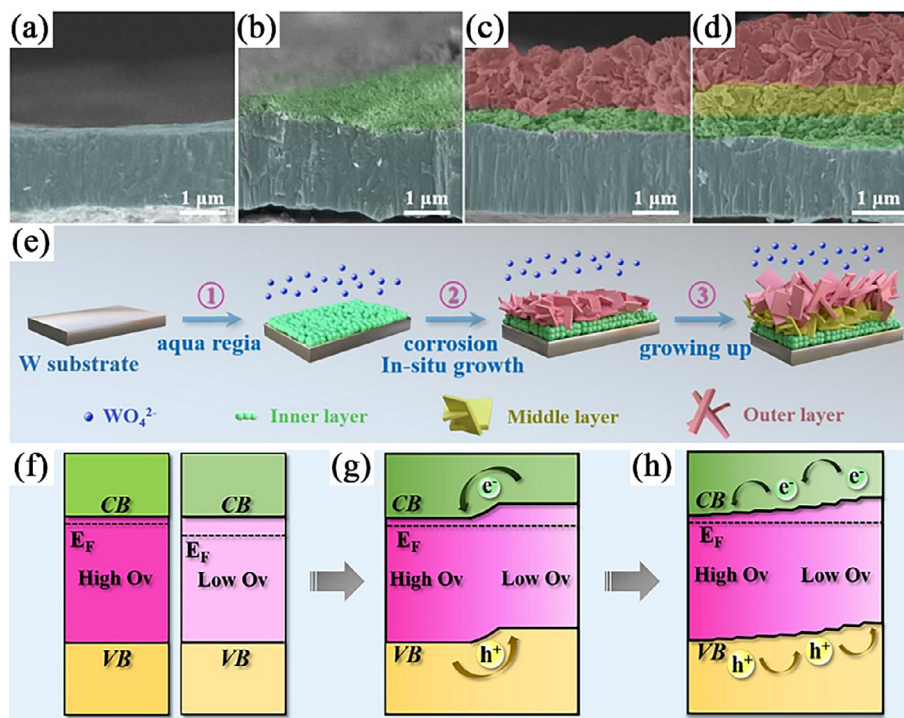
Although several co-catalysts have been used for the OER, for example,  $FeO_x$  [105],  $NiO_x$  [106],  $B_2O_{3-x}N_x$  [107], and mainly Co-Pi [104]; so far,  $CoO_x$  has been one of the most efficient co-catalysts for promoting  $O_2$  evolution [108]. In this regard, Hu and co-workers employed the organic linkage 3,3-diphosphonopropanate (C-M2P) to decorate the  $WO_3$  films with the  $CoO_x$  co-catalysts, which resulted in obtaining the system FTO/ $WO_3$ /C-M2P/ $CoO_x$  for PEC  $O_2$  generation in neutral media [109]. The authors demonstrated that M2P favoured the migration of holes, enabling an efficient charge collection across the photoelectrode. This allowed the photoanode to reach a high charge carrier density value of  $1.9 \times 10^{23} \text{ cm}^{-3}$  and passivation of the surface trap states. As a result, the  $WO_3$  films superficially modified with C-M2P/ $CoO_x$  reached an incredible  $\Delta j_{ph}$  of 3.5  $\text{mA cm}^{-2}$  at 1.23  $V_{RHE}$  and an IPCE of 71% at 400 nm. In terms of photostability, the  $\Delta j_{ph}$  maintained ca. 85% of its initial value during 10 h of constant illumination. Based on these figures, the C-M2P layer played a crucial role in the performance of the PEC system, especially when compared to  $WO_3$  films superficially modified with other oxide-based co-catalyst materials, such as PdO [100] and  $CoFe_2O_4$  [110].

In another study, Jim and co-workers used oxygen-rich carbon nitride quantum dots (CNQDs) to patch the  $WO_3$  nanoparticle disorder overlayer (DL- $WO_3$ ) since the presence of hole trapping sites harms the positive effect of oxygen vacancies toward  $WO_3$  photoelectrocatalytic activity (Fig. 11a and b) [111].

The authors reported that oxygen-rich CNQDs can chemisorb on oxygen vacancies to repair the DL- $WO_3$  via interaction of  $O^{-\delta}$  from the CNQDs with the  $W^{+6}$  atoms surrounded by oxygen vacancies. The removal of surface charge trap sites allowed to achieve one of the best PEC performances so far for a  $WO_3/QD$ , which reached a  $\Delta j_{ph}$  of 3.1  $\text{mA cm}^{-2}$  at 1.23  $V_{RHE}$  and IPCE of 97% at 380 nm, as presented in Fig. 11(c and d), respectively. In addition, as shown in Fig. 11(e), this system presented incredible long-term stability of 13.3 h ( $\Delta j_{ph}$  decayed  $\sim 10\%$  from its initial value).

This type of strategy involving the removal of oxygen vacancies has been recurrent in the past few years and its effect on the photoelectroactivity improvement of photoanodes based on metal oxides has been quite remarkable. Still concerning this type of strategy, other materials such as boron nitride quantum dots (BNQDs) [101] and nitrogen-doped carbon dot (N:CDs) [112] on  $WO_3$  films enabled obtaining excellent results of  $\Delta j_{ph}$  response improvement for water oxidation. All in all, these studies indicate that the combination of co-catalysts on the  $WO_3$  surface with the removal of oxygen vacancies in the bulk can be an excellent strategy to achieve even higher PEC performance and durability of  $WO_3$  films for water oxidation. A summary of the most recent surface modification strategies for  $WO_3$  films is listed in Table 5.

As presented so far, it is wide the possibilities to superficially modify the  $WO_3$  films. Fig. 12 presents the most relevant results about substrate influence, crystal plane growth control, defect engineering based on oxygen vacancies, doping, and surface modification strategies for  $WO_3$ -based photoanodes as a function of the elapsed stability time and the  $\Delta j_{ph}$  response before and after stability test at 1.23  $V_{RHE}$  which were referred to as initial and final  $\Delta j_{ph}$ , respectively. It bears repeating that the assembled PEC data in Fig. 12 aim to notice a possible general tendency of the results as a function of the modification strategies, systematic comparison is not intended here. Having that being clarified, according to Fig. 12, it is possible to point out that FTO may not be the best option as a substrate for the deposition of  $WO_3$  films, as the final



**Fig. 13.** (a–d) SEM micrographs for WO<sub>3</sub> photoanodes before and after reaction at 100 °C for 0.5, 1.5, and 3 h, respectively. (e) Schematic illustration of the growth mechanism of the sample WO<sub>3</sub>-100 via the hydrothermal process in aqua regia. (f–h) Schematic illustration of the energy band diagrams for WO<sub>3</sub> films without homojunction, with homojunction, and distributed homojunction, respectively. For all cases, the W substrate is located on the left. Reproduced from Ref. [116] with permission from Elsevier, Copyright 2020.

$\Delta j_{ph}$  was considerably smaller compared to the film grown on Ti substrate. Additionally, the crystal plane growth control deserves attention, the choice of a facet of the WO<sub>3</sub> can improve the  $\Delta j_{ph}$  by around 25%, comparing, for example, WO<sub>3</sub> [020] and WO<sub>3</sub> [002] [64]. Despite the broad options of surface modifications for WO<sub>3</sub> films, including the use of more than one layer of different metals, oxides and organics, in most cases, it did not bring an effective improvement in the  $\Delta j_{ph}$  for water splitting. Nevertheless, such superficial modifications allowed performing stability experiments for a longer period for, e.g., the FTO/DL-WO<sub>3</sub>/CNQDs system [106], compared to the bare WO<sub>3</sub> photoanodes [11,32,46,49,74,75].

### 3.3. Homojunction-based WO<sub>3</sub> photoanodes

The combination of two or more semiconductors with different optoelectronic properties is an approach widely used in the PEC field to improve the photocatalytic performance of PEC cells. In particular, the homojunction approach, which is the combination

of two semiconductors having a similar composition and/or crystalline structure, can promote continuity of band bonding and, consequently, provide a better charge transfer at the semiconductor|electrolyte interface [37]. Such a system also features having a built-in electric field to produce an adequate gradient of carrier concentration and to promote bulk charge separation away from the sites that induce recombination [38].

Li and co-workers used the multijunction strategy combined with doping to improve the charge separation and transfer efficiency of WO<sub>3</sub> films [115]. The authors firstly obtained the FTO/Mo:WO<sub>3</sub>/Fe:WO<sub>3</sub> based homojunction and then superficially modified it with nanoparticles of Bi<sub>2</sub>S<sub>3</sub> (FTO/Mo:WO<sub>3</sub>/Fe:WO<sub>3</sub>/Bi<sub>2</sub>S<sub>3</sub>). The homojunction Mo:WO<sub>3</sub>/Fe:WO<sub>3</sub> played an important role in the device performance since it showed an increase in bulk charge separation and transfer efficiencies, which was due to the occurrence of a built-in electric field or an enhanced (quasi-)Fermi level gradient at Mo:WO<sub>3</sub>|Fe:WO<sub>3</sub> homojunction interface. The homojunction (Mo:WO<sub>3</sub>/Fe:WO<sub>3</sub>) provided additional improvement of

**Table 6**  
Summary of homojunction-based WO<sub>3</sub> photoanodes for PEC water splitting application.

Material	WO <sub>3</sub> fabrication method	WO <sub>3</sub> morphology	Electrolyte	Illumination	Notable PEC results	Ref.
FTO/Mo:WO <sub>3</sub> /Fe:WO <sub>3</sub> /Bi <sub>2</sub> S <sub>3</sub>	Hydrothermal	Nanorods	0.2 M Na <sub>2</sub> SO <sub>4</sub>	Xe lamp AM1.5G 100 mW cm <sup>-2</sup>	2.55 mA cm <sup>-2</sup> at 1.23 V <sub>RHE</sub> ABPE 0.35% at 0.68 V <sub>RHE</sub> IPCE ~45% at 300–400 nm (1.23 V <sub>RHE</sub> ) Stability test for 2 h (decayed ~10%)	[115]
W/WO <sub>3</sub>	Hydrothermal	Nanoplates	0.5 M Na <sub>2</sub> SO <sub>4</sub>	300 W Xe lamp AM1.5G 100 mW cm <sup>-2</sup>	1.81 mA cm <sup>-2</sup> at 1.23 V <sub>RHE</sub> IPCE ~62% at 380 nm (1.23 V <sub>RHE</sub> )	[116]
FTO/1D-WO <sub>3</sub> /2D-WO <sub>3-x</sub>	Hydrothermal	Nanorods and nanoflakes	0.2 M Na <sub>2</sub> SO <sub>4</sub>	300 W Xe lamp AM1.5G 100 mW cm <sup>-2</sup>	0.98 mA cm <sup>-2</sup> at 1.23 V <sub>RHE</sub> IPCE ~32.2% at 350 nm (1.23 V <sub>RHE</sub> ) Stability test for 2 h (decayed ~50%)	[117]
FTO/WO <sub>3</sub> (002)/m-WO <sub>3</sub>	Solvothermal/ Spin coating	Nanoparticles	0.1 M Na <sub>2</sub> SO <sub>4</sub>	300Xe lamp AM1.5G 100 mW cm <sup>-2</sup>	1.1 mA cm <sup>-2</sup> at 1.23 V <sub>RHE</sub> Stability test for 2 h (decayed ~14%)	[118]

carrier transfer by its unique property of minimization of lattice mismatch. Further PEC enhancement was achieved in the presence of the Bi<sub>2</sub>S<sub>3</sub> nanoparticles, which enabled improving carrier separation and transportation and inhibited their recombination due to the band alignment in the Fe:WO<sub>3</sub>/Bi<sub>2</sub>S<sub>3</sub> heterojunction. In terms of photoresponse, the device provided a  $\Delta j_{\text{ph}}$  of 2.55 mA cm<sup>-2</sup> at 1.23 V<sub>RHE</sub> and stability of 2 h ( $\Delta j_{\text{ph}}$  retention of ~90% from its initial value). In short, the homojunction's well-matched staggered alignment band structure allowed electrons and holes to migrate more easily between Mo:WO<sub>3</sub> and Fe:WO<sub>3</sub> bands and led to better PEC performance.

Ma and co-workers have grown hierarchical layers of WO<sub>3</sub> on tungsten substrate by the one-step aqua-regia hydrothermal method [116]. This approach allowed obtaining homojunction-based WO<sub>3</sub> photoanode with different layer sizes featuring an inner layer of nanoparticles, a middle layer of structured multi-layer, and an outer layer of nanosheet arrays (Fig. 13).

The authors learned from the XPS analyses that the presence of distributed homojunction caused an oxygen vacancy gradient across the layers, namely high and low O<sub>v</sub> as shown in Fig. 13(f and g). Such gradient resulted in the formation of a spatially distributed built-in electric field or an enlarged distributed (quasi-) Fermi level gradient which greatly allowed improvement of PEC water splitting. In another study, a new design of homojunction-based WO<sub>3</sub> photoanodes was built to improve the charge separation and transfer for an efficient PEC O<sub>2</sub> evolution. In this case, Li and co-workers proposed a homojunction consisting of 2D nonstoichiometric WO<sub>3-x</sub> nanoflakes that are vertically grown on 1D WO<sub>3</sub> nanorods [117]. Interestingly, the larger active area of the 2D structure maximized light collection and the 1D structure benefited the charge transfer. Additionally, the homojunction formed between these structures improved the charge separation efficiency.

In these studies presented, several benefits were attributed when employing a homojunction of WO<sub>3</sub>, such as high rates of light-harvesting and solar conversion, and improved stability. Although Mo:WO<sub>3</sub>/Fe:WO<sub>3</sub>/Bi<sub>2</sub>S<sub>3</sub> and W/WO<sub>3</sub> hierarchical systems presented higher  $\Delta j_{\text{ph}}$  values, only the 1D-WO<sub>3</sub>/2D-WO<sub>3-x</sub> photoanode maintained its integrity during stability assessments. Its durability may be associated with the different morphologies obtained from the homojunction and deserves a more in-depth investigation to obtain an even further PEC improvement. A summary of homojunction-based WO<sub>3</sub> photoanodes for PEC O<sub>2</sub> generation is displayed in Table 6.

### 3.4. Heterojunction-based WO<sub>3</sub> photoanodes

The employment of heterojunctions allows combining different properties of semiconductors to produce unique optoelectronic characteristics that are not available in each semiconductor. These benefits are due to the appropriate combination of the energy band levels of each semiconductor, and it is necessary to have a nearly-matched overlapping band structure [119]. Such an approach can potentially enable improvement in photocatalytic performance due to broadening light-harvesting, minimization of recombination process, improving photogenerated charges separation efficiency, and suppression of photocorrosion process [12,14,120].

Depending on the valence and conduction band positions of a semiconductor compared to another one in a heterostructure, different types of heterostructure can arise such as type II heterostructure [120]. In this configuration, the CB and VB of a given semiconductor are more negative than the respective bands of the other semiconductor. Such band arrays allow the transport of the photogenerated electron and holes in opposite directions, which hinder carriers' recombination and favour PEC water splitting [121]. In terms of semiconductor materials, i.e., WO<sub>3</sub> films, applied in the heterostructure, the WO<sub>3</sub>/BiVO<sub>4</sub> [122] and WO<sub>3</sub>/

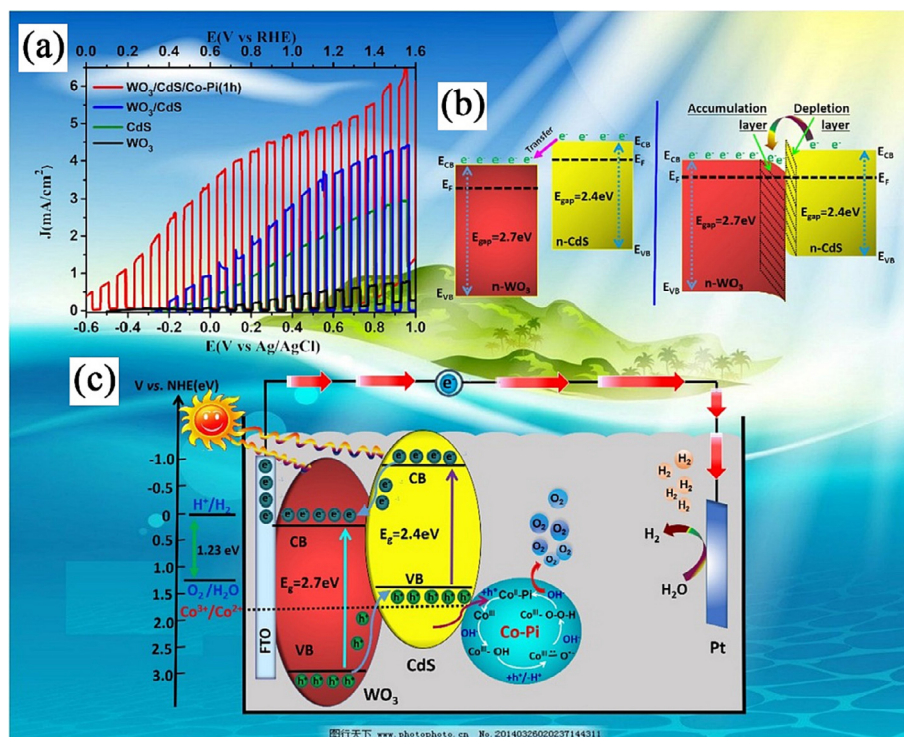
Fe<sub>2</sub>O<sub>3</sub> [123] systems are the most widely used for PEC water photoelectrooxidation. In addition to the heterostructure approach, Z-scheme is another strategy highly considered as it has demonstrated to be effective to provide improvement for PEC water splitting. For such a system, the WO<sub>3</sub>/g-C<sub>3</sub>N<sub>4</sub> [124], WO<sub>3</sub>/Cu<sub>2</sub>O [125], and BiVO<sub>4</sub>/W/WO<sub>3</sub> [126] have recently emerged as new Z-scheme configurations for an efficient PEC water photoelectrooxidation.

In addition to the presented heterostructure-based WO<sub>3</sub> films, several notable heterojunctions have recently been reported in the literature, mainly the ones consisting of transition metal dichalcogenides (TMD) such as WS<sub>2</sub>. This material features having a high catalytic activity which makes it a promising material for water photoelectrooxidation. Employing WS<sub>2</sub>, Tayebi and co-workers proposed the manufacture of the WO<sub>3</sub>/WS<sub>2</sub> featuring nanosheet structure, which was prepared by liquid-phase exfoliation combined with ultrasonication [127]. The high PEC performance was attributed to the presence of WS<sub>2</sub> nanosheets, being responsible for the increase in light-harvesting, enhanced charge separation and transport, and band alignment. Despite this system delivering a substantial  $\Delta j_{\text{ph}}$  of 5.6 mA cm<sup>-2</sup> at 1.23 V<sub>Ag/AgCl</sub>, photostability stood as an issue to be overcome. In another study, Mojaddami and Simchi produced a mixture of WS<sub>2</sub> and MoS<sub>2</sub> which was loaded on W/WO<sub>3</sub> films via cathodic electrophoretic deposition [128]. The prepared system presented a  $\Delta j_{\text{ph}}$  of ~1.7 mA cm<sup>-2</sup> at 1.23 V<sub>RHE</sub> and a substantial current density of 14.9 mA cm<sup>-2</sup> at 1.23 V<sub>RHE</sub>, which indicates that the combination of these TMDs can promote a high electrocatalytic activity for OER. Furthermore, the heterostructure remained stable for 2.8 h. Another TMD-based heterostructure comprised of WO<sub>3</sub>/VS<sub>2</sub> was obtained by Moi and co-workers [129]. The authors demonstrated that the presence of VS<sub>2</sub> acted as a hole trapping agent of the WO<sub>3</sub> valence band and that it favoured kinetics for OER. Moreover, VS<sub>2</sub> presented active sites on the edge and basal planes for the occurrence of OER [130]. In terms of photoresponse for the OER, the FTO/WO<sub>3</sub>/VS<sub>2</sub> film displayed a  $\Delta j_{\text{ph}}$  of 2.2 mA cm<sup>-2</sup> at 1.23 V<sub>RHE</sub> which was ~5.4 times higher than for the unmodified WO<sub>3</sub> film.

Hosseini and co-workers have investigated the use of organic/inorganic semiconductors based on polyaniline/WO<sub>3</sub> (PANI/WO<sub>3</sub>) for PEC water oxidation. In 2019, the authors manufactured camphor sulfonic acid doped polyaniline/WO<sub>3</sub> modified with rGO (CSA:PANI/WO<sub>3</sub>/rGO) and obtained an increasing improvement in the photocatalytic activity as each layer was deposited [131]. The rGO incorporation on CSA:PANI/WO<sub>3</sub> promoted improvements in the charge separation and transfer kinetics at the photoelectrode|electrolyte interface, making OER more feasible. Lately, the author has modified the PANI/WO<sub>3</sub> system with the (6,6)-phenyl-C61-butiric acid methyl ester (PC61BM) and achieved higher rates of water photoelectrooxidation [132]. This improvement was assigned to the PC61BM which is a fullerene derivative that enabled better electron accepting capability and electron mobility compared to C60 [132,133]. Employing this type of superficial modification (i.e., PC61BM), provided several benefits to the system, such as high electrical conductivity and carrier mobility, smaller E<sub>g</sub>, and larger surface area, which led to an improved  $\Delta j_{\text{ph}}$  of 1.63 mA cm<sup>-2</sup> at 1.23 V<sub>RHE</sub>. In short, organic/inorganic semiconductors have shown promising photoelectrocatalysts features as well as being a noble metal-free alternative for an efficient PEC solar water splitting.

Another interesting heterostructure that deserves attention is the one made up of WO<sub>3</sub>/CdS. Recently, two works have been published using WO<sub>3</sub> photoanodes coated with CdS that were obtained by hydrothermal method [134] and successive ionic layer adsorption and reaction [135]. For one of these studies, an additional layer of Co-Pi co-catalyst was deposited over the heterostructure and that enabled achieving a noticeable  $\Delta j_{\text{ph}}$  of 5.85 mA cm<sup>-2</sup> at 1.23





**Fig. 14.** (a) Linear sweep voltammograms at  $20 \text{ mV s}^{-1}$  and under chopped solar light simulator for  $\text{WO}_3$ , CdS,  $\text{WO}_3/\text{CdS}$ , and  $\text{WO}_3/\text{CdS}/\text{Co-Pi}$  (1 h) films. The electrolyte was a PBS of 0.5 M  $\text{Na}_2\text{SO}_3$  at pH 7. Schematic diagrams for (b)  $\text{WO}_3/\text{CdS}$  and (c)  $\text{WO}_3/\text{CdS}/\text{Co-Pi}$  systems. Reproduced from Ref. [134] with permission from Elsevier, Copyright 2019.

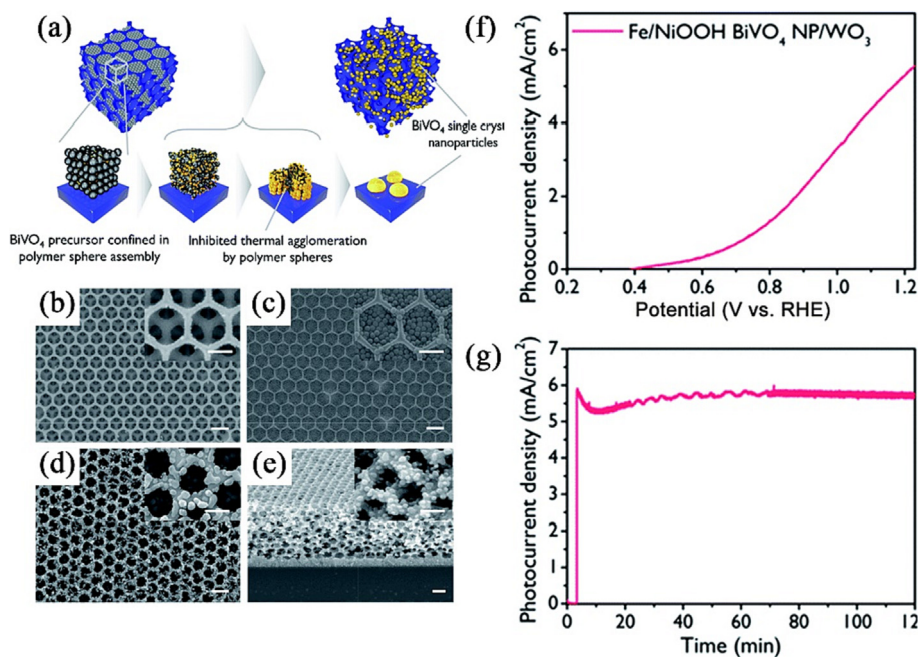
$V_{\text{RHE}}$  (cf. Fig. 14a). Most impressive, the optimized condition provided shifting the  $E_{\text{on}}$  in 529 mV towards less positive values and this was due to the presence of both CdS and mainly Co-Pi. Regarding the stability test, the  $\Delta j_{\text{ph}}$  response maintained  $\sim 85\%$  of its initial value once elapsed 1.1 h. For the improved photoelectroactivity and stability, the authors reported that was due to the presence of CdS that created a built-in electric field or a (quasi-)Fermi level gradient at the  $\text{WO}_3/\text{CdS}$  interface, which provided improving the separation of the photogenerated charges. Despite this improvement in carrier separation, the photogenerated holes tended to accumulate in the CdS valence band, which led to the electron-hole recombination process due to the sluggish OER. Such an issue was overcome by depositing the Co-Pi over the heterostructure which enabled improvement of carriers transfer and consequently enhanced PEC performance for water oxidation (see Fig. 14b and c) [134].

In another study, Li and co-workers added a dual-layer cocatalyst consisting of NiOOH (as hole storage layer) and Co-Pi (as hole transfer layer) on  $\text{WO}_3/\text{CdS}$  films [135]. The FTO/ $\text{WO}_3/\text{CdS}/\text{NiOOH}/\text{Co-Pi}$  system displayed a  $\Delta j_{\text{ph}}$  of  $2.59 \text{ mA cm}^{-2}$  at  $1 \text{ V}_{\text{RHE}}$  and stability of 1.9 h (the  $\Delta j_{\text{ph}}$  decayed  $\sim 8\%$  from its initial value). It is also worth highlighting the study reported by Lin and co-workers about the manufacture of the heterostructure-based  $\text{WO}_3/\text{Fe}_2\text{WO}_6$  by combining hydrothermal and spray pyrolysis processes [136]. The obtained heterojunction provided a wider light absorption range and the presence of a built-in electric field or a (quasi-)Fermi level gradient enabled a more efficient separation and transportation of the minority carriers from the  $\text{WO}_3$  to the  $\text{Fe}_2\text{WO}_6$ . Further PEC improvement of this system was achieved by doping the  $\text{WO}_3$  films with Fe ions and this resulted in increasing the electrical conductivity, charge transport and transfer at the photoelectrode/electrolyte interface, and enhanced charge carrier diffusion and lifetime. The authors also deposited a cocatalyst layer of FeOOH/NiOOH over the  $\text{Fe}:\text{WO}_3/\text{Fe}_2\text{WO}_6$  films, which enabled reducing interfacial recombination and accelerating PEC water oxidation reaction. In terms of photoresponse, the combina-

tion of band structure engineering with doping and deposition of suitable OER co-catalysts resulted in a  $\Delta j_{\text{ph}}$  of  $2.78 \text{ mA cm}^{-2}$  at  $1.23 \text{ V}_{\text{RHE}}$  and remarkable stability of 4 h (the  $\Delta j_{\text{ph}}$  decayed  $\sim 3\%$  from its initial value).

Among all the  $\text{WO}_3$ -based heterostructures mentioned so far, those composed of hematite ( $\text{Fe}_2\text{O}_3$ ) and  $\text{BiVO}_4$  are among the most widely used and promising photoanodes for PEC water splitting. Hematite has several qualities that make it one of the most promising candidates for photoelectrooxidation of water. In addition to its earth-abundant chemical elements, low cost, and is non-toxic, it has important aspects that can be highlighted, such as adequate optical  $E_g$  (1.9–2.2 eV) and high stability in neutral and alkaline media [137]. Despite this, hematite still faces several barriers that make it far from its maximum theoretical conversion efficiency of solar to chemical energy, such as slow water oxidation kinetics, the short hole diffusion length of photogenerated charge carriers, short lifetime and poor mobility of charge carriers [138,139].

Kim and co-workers developed a core-shell structure of an ultrathin layer of  $\text{Fe}_2\text{O}_3$  deposited by ALD over mesoporous  $\text{WO}_3$  grown on FTO (FTO/ $\text{WO}_3/\text{Fe}_2\text{O}_3$ ) [123]. This heterostructure system allowed shifting the  $E_{\text{on}}$  towards less positive potential values in comparison with the  $\text{Fe}_2\text{O}_3$  and it was assigned to the occurrence of a type II heterostructure and the formation of a strong built-in electric field in the SCR. The mesoporous scaffold structure photoanode also allowed multiple light absorption and reached a  $\Delta j_{\text{ph}}$  of  $0.83 \text{ mA cm}^{-2}$  at  $1.23 \text{ V}_{\text{RHE}}$ , which was higher than the bare  $\text{Fe}_2\text{O}_3$  film. Further PEC improvement of this heterostructure was achieved in terms of minimization of charge recombination via deposition of an overlayer of  $\text{TiO}_2$  and a cobalt phosphate (Co-Pi) cocatalyst layer [140]. When combined all the optimizations to obtain the FTO/ $\text{WO}_3/\text{Fe}_2\text{O}_3/\text{TiO}_2/\text{Co-Pi}$  photoanode, the maximum  $\Delta j_{\text{ph}}$  was achieved, reaching  $1.5 \text{ mA cm}^{-2}$  at  $1.23 \text{ V}_{\text{RHE}}$  and  $4.1 \text{ mA cm}^{-2}$  at  $1.7 \text{ V}_{\text{RHE}}$ . The authors proposed the formation of a type II heterojunction between the  $\text{WO}_3$  and  $\text{Fe}_2\text{O}_3$ , which resulted in an improved charge separation due to the strong built-in electric field or the enlarged (quasi-)Fermi level gradient



**Fig. 15.** (a) Schematic representation for the fabrication of the WO<sub>3</sub>/BiVO<sub>4</sub> porous nanostructure. SEM micrographs for the (b) WO<sub>3</sub> porous structure, (c) WO<sub>3</sub> infiltrated with the polystyrene colloid, (d) WO<sub>3</sub>/Mo:BiVO<sub>4</sub> structure, and (e) cross-sectional SEM image for the WO<sub>3</sub>/Mo:BiVO<sub>4</sub>. The scale bars are 1 μm and the insets are their magnified images with scale bars of 0.5 μm. (f) Linear sweep voltammograms under solar light simulator (AM1.5G and 100 mW cm<sup>-2</sup>) and (g) PEC stability at 1.23 V<sub>RHE</sub> and under solar light simulator (AM1.5G and 100 mW cm<sup>-2</sup>) for the WO<sub>3</sub>/Mo:BiVO<sub>4</sub>/FeOOH/NiOOH. The electrolyte was a solution of 0.5 M Na<sub>2</sub>SO<sub>4</sub> and 0.1 M Na<sub>2</sub>SO<sub>3</sub> at pH 7. Reproduced (adapted) from Ref. [148] with permission from Royal Society of Chemistry, Copyright 2019.

in the SCR [123,141]. Additionally, the thin TiO<sub>2</sub> overlayer introduced a built-in potential that reduced the hole trap in the Fe<sub>2</sub>O<sub>3</sub> surface, while the Co-Pi acted as a hole-transfer co-catalyst which provided a faster hole transfer at the photoanode|electrolyte interface [123].

Wu and co-workers also reported a type II heterojunction made up of WO<sub>3</sub>/Ti-Fe<sub>2</sub>O<sub>3</sub> in which both materials are n-type semiconductors [140]. The WO<sub>3</sub> films were grown by hydrothermal method, which consisted of placing the clean FTO substrates in the vessel containing the precursor solution at 120 °C for 2 h. The Ti-Fe<sub>2</sub>O<sub>3</sub> was also deposited over the WO<sub>3</sub> nanosheet array via the hydrothermal method with subsequent annealing at 550 °C. In this work, the authors compared the Δ*j*<sub>ph</sub> of the Ti-Fe<sub>2</sub>O<sub>3</sub> film deposited on FTO and FTO/WO<sub>3</sub>. The FTO/WO<sub>3</sub>/Ti-Fe<sub>2</sub>O<sub>3</sub> photoanode reached a Δ*j*<sub>ph</sub> of 2.15 mA cm<sup>-2</sup> at 1.23 V<sub>RHE</sub>, which was ~4 times higher than the Ti-Fe<sub>2</sub>O<sub>3</sub> deposited over FTO. The heterostructured photoanode also showed great stability, which kept almost constant a Δ*j*<sub>ph</sub> of 2.5 mA cm<sup>-2</sup> at 1.23 V<sub>RHE</sub> for 1.9 h. The WO<sub>3</sub>/Ti-Fe<sub>2</sub>O<sub>3</sub> heterojunction also displayed an increase of 45% in the photon-to-current efficiency, which was attributed to the improvement of charge separation and charge transfer yields. In addition, the electrochemical impedance spectroscopy results indicated that this heterojunction allowed a faster hole transfer at the photoanode|electrolyte interface.

In another study, Fan and co-workers obtained nanoarrays of WO<sub>3</sub> onto FTO substrate by hydrothermal method followed by deposition of the Fe<sub>2</sub>O<sub>3</sub> thin layer by spin coating (FTO/WO<sub>3</sub>/Fe<sub>2</sub>O<sub>3</sub>) [142]. The authors compared the photoelectroactivity of the FTO/WO<sub>3</sub>/Fe<sub>2</sub>O<sub>3</sub> with the individual materials and studied the optimal load of Fe<sub>2</sub>O<sub>3</sub> varying the spin coating by 10, 20, and 50 times. The optimized FTO/WO<sub>3</sub>/Fe<sub>2</sub>O<sub>3</sub> photoanodes (spin-coated Fe<sub>2</sub>O<sub>3</sub> for 20 times) showed by the PEC experiments that the formation of the core-shell heterojunction not only improved the Δ*j*<sub>ph</sub>, reaching 1.29 mA cm<sup>-2</sup> at 1.23 V<sub>RHE</sub>, but also resulted in shifting the *E*<sub>on</sub> in 210 mV towards less positive values. Despite these improvements, the Δ*j*<sub>ph</sub> of the FTO/WO<sub>3</sub>/Fe<sub>2</sub>O<sub>3</sub> at the lower poten-

tial region was slightly lower than the bare WO<sub>3</sub>, which was attributed to a large number of surface states in the Fe<sub>2</sub>O<sub>3</sub>. To overcome this issue was deposited a co-catalyst comprised of NiFe-layered double hydroxide (NiFe-LDH), which contributed to shifting the *E*<sub>on</sub> in 50 mV to less positive values and substantially increase of the Δ*j*<sub>ph</sub> at relative lower potentials. The FTO/WO<sub>3</sub>/Fe<sub>2</sub>O<sub>3</sub> and FTO/WO<sub>3</sub>/Fe<sub>2</sub>O<sub>3</sub>/NiFe-(LDH) also presented great stability, maintaining 73% and 94.5% of their Δ*j*<sub>ph</sub> for 1 h, respectively.

Concerning the WO<sub>3</sub>/BiVO<sub>4</sub> heterostructure, BiVO<sub>4</sub> is an n-type semiconductor with a narrow direct optical *E*<sub>g</sub> of ~2.4 eV for its monoclinic phase, which is ideal for absorbing photons in the visible range of the solar spectrum. BiVO<sub>4</sub> has also shown excellent results, such as featuring STH exceeding 4% in devices based on dual-photoelectrodes only assisted by solar light [143]. Additionally, the CB and VB positions of this material are suitably positioned to construct a type-II heterostructure with WO<sub>3</sub> [144]. Since BiVO<sub>4</sub> has poor charge separation, the combination of its optoelectronic properties with those of WO<sub>3</sub> can potentially overcome this issue by enabling rapid charge separation at the heterojunction interface [144–146]. This makes WO<sub>3</sub>/BiVO<sub>4</sub> heterojunction one of the most explored systems in the literature [147].

One of the highest Δ*j*<sub>ph</sub> results obtained so far for the WO<sub>3</sub>/BiVO<sub>4</sub> system was achieved by Kim and co-workers, which employed a WO<sub>3</sub> scaffold coated with nanoparticles of Mo:BiVO<sub>4</sub> (cf. Fig. 15a–e) [148]. The scaffold was obtained via drop-casting of WO<sub>3</sub> precursor solution onto colloidal crystal-coated FTO substrate [148]. Subsequently, the authors photoelectrodeposited a dual-layer of FeOOH/NiOOH over the FTO/WO<sub>3</sub>/Mo:BiVO<sub>4</sub> films. This system delivered a substantial Δ*j*<sub>ph</sub> of 5.8 mA cm<sup>-2</sup> at 1.23 V<sub>RHE</sub> for water oxidation and was stable for 2 h, as shown in Fig. 15(f and g), respectively. The results also indicated that charge transport occurs more efficiently in BiVO<sub>4</sub> nanoparticles than in a continuous shell. Furthermore, the light absorption efficiency of the system was improved due to the nanoparticles of BiVO<sub>4</sub> that enhanced Rayleigh-type light scattering, mainly at the absorption edge wavelengths.

**Table 7**  
Summary of heterojunction-based WO<sub>3</sub> photoanodes for PEC water splitting application.

Material	WO <sub>3</sub> fabrication method	WO <sub>3</sub> morphology	Electrolyte	Illumination	Notable PEC results	Ref.
W/WO <sub>3</sub> /WS <sub>2</sub>	Sonochemically assisted method	Nanoplates	0.5 M Na <sub>2</sub> SO <sub>4</sub>	300 W Xe lamp AM1.5G 100 mW cm <sup>-2</sup>	5.6 mA cm <sup>-2</sup> at 1.23 V <sub>Ag/AgCl</sub> IPCE 55.2% at 350 nm (0.6 V <sub>Ag/AgCl</sub> ) ABPE 2.26% at 0.75 V <sub>Ag/AgCl</sub>	[127]
W/WO <sub>3</sub> /WS <sub>2</sub> -MoS <sub>2</sub>	Hydrothermal	Nanoflakes	0.5 M H <sub>2</sub> SO <sub>4</sub>	350 W Xe lamp 100 mW cm <sup>-2</sup>	~1.7 mA cm <sup>-2</sup> at 1.23 V <sub>RHE</sub> Stability test for 2.8 h (approx. const.)	[128]
FTO/WO <sub>3</sub> /VS <sub>2</sub>	Hydrothermal	Nanoflakes	0.1 M Na <sub>2</sub> SO <sub>4</sub>	300 W W lamp 100 mW cm <sup>-2</sup>	2.2 mA cm <sup>-2</sup> at 1.23 V <sub>RHE</sub> IPCE 23% at 350 nm	[129]
FTO/WO <sub>3</sub> /In <sub>2</sub> S <sub>3</sub>	Hydrothermal	Nanowalls	0.1 M Na <sub>2</sub> SO <sub>4</sub>	Xe lamp AM1.5G 100 mW cm <sup>-2</sup>	1.61 mA cm <sup>-2</sup> at 1.23 V <sub>RHE</sub> E <sub>on</sub> = 0.02 V <sub>RHE</sub> ABPE 0.29% at 0.88 V <sub>RHE</sub>	[153]
FTO/WO <sub>3</sub> /CdIn <sub>2</sub> S <sub>4</sub>	Hydrothermal	Nanowalls	0.25 M Na <sub>2</sub> SO <sub>4</sub>	AM1.5G 100 mW cm <sup>-2</sup>	1.06 mA cm <sup>-2</sup> at 1.23 V <sub>RHE</sub> E <sub>on</sub> = 0.14 V <sub>RHE</sub> IPCE 41.5% at 360 nm (1.23 V <sub>RHE</sub> )	[154]
FTO/WO <sub>3</sub> /ZnIn <sub>2</sub> S <sub>4</sub> /AESI <sup>a</sup> ( <sup>a</sup> AESI: N-(2-aminoethyl)-3-aminopropyltrimethoxysilane)	Hydrothermal	Nanosheets	0.5 M Na <sub>2</sub> SO <sub>4</sub>	AM1.5G 100 mW cm <sup>-2</sup>	1.51 mA cm <sup>-2</sup> at 1.23 V <sub>RHE</sub> E <sub>on</sub> = 0.4 V <sub>RHE</sub> IPCE 50.6% at 365 nm (1.23 V <sub>RHE</sub> ) ABPE 0.19% at ~0.95 V <sub>RHE</sub> Stability test for 1 h (decayed ~50%)	[155]
ITO/CSA:PANI-WO <sub>3</sub> /rGO	WO <sub>3</sub> nanoparticles/spin coating	Pellet-like nanoparticles	0.1 M Na <sub>2</sub> SO <sub>4</sub>	300 W Xe lamp 100 mW cm <sup>-2</sup>	1.54 mA cm <sup>-2</sup> at 1.23 V <sub>RHE</sub> ABPE 0.29% at ~0.85 V <sub>RHE</sub>	[131]
ITO/PANI-WO <sub>3</sub> /PC61BM	WO <sub>3</sub> nanoparticules/spin coating	Nanoparticles	0.1 M Na <sub>2</sub> SO <sub>4</sub>	300 W Xe lamp 100 mW cm <sup>-2</sup>	1.63 mA cm <sup>-2</sup> at 1.23 V <sub>RHE</sub>	[132]
FTO/CuWO <sub>4</sub> /WO <sub>3</sub>	Hydrothermal	Urchin-like	0.2 M PBS pH 7	300 W Xe lamp AM1.5G	0.48 mA cm <sup>-2</sup> at 1.23 V <sub>RHE</sub> E <sub>on</sub> = 0.6 V <sub>RHE</sub> Stability test for 3 h (decayed ~20%)	[156]
FTO/WO <sub>3</sub> /CuWO <sub>4</sub> /Co-Pi	Hydrothermal	Nanoplates	0.2 M Na <sub>2</sub> SO <sub>4</sub>	AM1.5G 100 mW cm <sup>-2</sup>	1.4 mA cm <sup>-2</sup> at 1.23 V <sub>RHE</sub> ABPE 0.55% at ~0.70 V <sub>RHE</sub> Stability test for 2 h (decayed ~10%)	[157]
FTO/WO <sub>3</sub> /rocksalt-CoO <sub>x</sub>	Hydrothermal	Nanoplates	0.5 M Na <sub>2</sub> SO <sub>4</sub>	300 W Xe lamp AM1.5G 100 mW cm <sup>-2</sup>	0.53 mA cm <sup>-2</sup> at 1.23 V <sub>RHE</sub> IPCE 23.5% at 350 nm ABPE 0.062% at 1.03 V <sub>RHE</sub>	[158]
FTO/WO <sub>3</sub> /CdS/Co-Pi	Hydrothermal	Plates	0.1 PBS + 0.5 M Na <sub>2</sub> SO <sub>3</sub>	300 W Xe lamp AM1.5G 100 mW cm <sup>-2</sup>	5.85 mA cm <sup>-2</sup> at 1.23 V <sub>RHE</sub> IPCE 41.8% at 420 nm (1.23 V <sub>RHE</sub> ) ABPE 1.80% at 0.7 V <sub>RHE</sub> Stability test for 1.1 h (decayed ~15%)	[134]
FTO/WO <sub>3</sub> /CdS/NiOOH/Co-Pi	Hydrothermal	Nanorods	0.2 M Na <sub>2</sub> SO <sub>4</sub>	AM1.5G 100 mW cm <sup>-2</sup>	2.59 mA cm <sup>-2</sup> at 1 V <sub>RHE</sub> LHE 90% at 300–450 nm ABPE 1.02% at 0.64 V <sub>RHE</sub> E <sub>on</sub> ≈ 0.3 V <sub>RHE</sub> Stability test for 1.9 h (decayed ~8%)	[135]
FTO/WO <sub>3</sub> /Bi <sub>2</sub> O <sub>2</sub> NCN	Hydrothermal	Not informed	0.1 M potassium phosphate (KPi)	450 W Xe lamp AM1.5G 100 mW cm <sup>-2</sup>	1.11 mA cm <sup>-2</sup> at 1.23 V <sub>RHE</sub> IPCE ~10.5% at 380 nm (1.23 V <sub>RHE</sub> ) Stability test for ~0.33 h (decayed ~25%)	[159]
FTO/WO <sub>3</sub> /NiCo <sub>2</sub> O <sub>4</sub>	Hydrothermal	Nanoplates	0.2 M Na <sub>2</sub> SO <sub>4</sub>	AM1.5G 100 mW cm <sup>-2</sup>	0.84 mA cm <sup>-2</sup> at 1.23 V <sub>RHE</sub> Stability test for 2 h (decayed ~10%)	[160]
FTO/WO <sub>3</sub> /Ni(OH) <sub>2</sub>	Hydrothermal	Blocks and sheets	0.5 M Na <sub>2</sub> SO <sub>4</sub>	300 W Xe lamp AM1.5G 100 mW cm <sup>-2</sup>	1 mA cm <sup>-2</sup> at 0.8 V <sub>RHE</sub> E <sub>on</sub> = 0.3 V <sub>RHE</sub>	[161]
FTO/Fe:WO <sub>3</sub> /Fe <sub>2</sub> WO <sub>6</sub> /FeOOH/NiOOH	Hydrothermal	Nanosheets	0.5 M PBS pH 7	450 W Xe lamp AM1.5G 100 mW cm <sup>-2</sup>	2.78 mA cm <sup>-2</sup> at 1.23 V <sub>RHE</sub> ABPE 0.72% at 0.8 V <sub>RHE</sub> Stability test for 4 h (approx. const.)	[136]

Table 7 (continued)

Material	WO <sub>3</sub> fabrication method	WO <sub>3</sub> morphology	Electrolyte	Illumination	Notable PEC results	Ref.
FTO/WO <sub>3</sub> /rGO/Ni:FeOOH	Hydrothermal	Nanoflakes	0.5 M Na <sub>2</sub> SO <sub>4</sub>	Xe lamp 100 mW cm <sup>-2</sup>	1.32 mA cm <sup>-2</sup> at 1.23 V <sub>RHE</sub> IPCE 96.% at 380 nm Stability test for 6 h (decayed ~5%)	[162]
FTO/WO <sub>3</sub> /CQDs/NiFe	Solvothermal	Nanoflakes	0.2 M Na <sub>2</sub> SO <sub>4</sub>	300 W Xe lamp AM1.5G 100 mW cm <sup>-2</sup>	1.43 mA cm <sup>-2</sup> at 1.23 V <sub>RHE</sub> IPCE 38.6% at 405 nm (1.23 V <sub>RHE</sub> ) ABPE 0.16% at 1 V <sub>RHE</sub> Stability test for 3 h (approx. const)	[163]
FTO/WO <sub>3</sub> /α-Fe <sub>2</sub> O <sub>3</sub> /TiO <sub>2</sub> /Co-Pi	Drop-casting/sol-gel	Mesoporous/nanoparticles	1 M NaOH	AM1.5G 100 mW cm <sup>-2</sup>	1.5 mA cm <sup>-2</sup> at 1.23 V <sub>RHE</sub> IPCE ~17.5% at 300–400 nm (1.23 V <sub>RHE</sub> ) Stability test for 1.7 h (decayed ~10%)	[123]
FTO/WO <sub>3</sub> /Fe <sub>2</sub> O <sub>3</sub>	Hydrothermal	Cuboid sheets	1 M NaOH	AM1.5G 100 mW cm <sup>-2</sup>	0.78 mA cm <sup>-2</sup> at 0.8 V <sub>Ag/AgCl</sub> Stability test for 0.28 h (decayed ~70%)	[164]
FTO/WO <sub>3</sub> /Ti-Fe <sub>2</sub> O <sub>3</sub>	Hydrothermal	Nanosheets	1 M KOH	300 W Xe lamp AM1.5G 100 mW cm <sup>-2</sup>	2.15 mA cm <sup>-2</sup> at 1.23 V <sub>RHE</sub> IPCE ~60% at 370 nm (1.23 V <sub>RHE</sub> ) E <sub>on</sub> = 0.92 V <sub>RHE</sub> Stability test for 1.95 h (decayed ~20%)	[140]
FTO/WO <sub>3</sub> /Fe <sub>2</sub> O <sub>3</sub> /NiFe-LDH	Hydrothermal	Nanorods	Not informed	150 W Xe lamp AM1.5G	1.29 mA cm <sup>-2</sup> at 1.23 V <sub>RHE</sub> E <sub>on</sub> = 0.65 V <sub>RHE</sub> IPCE 26% at 350 nm (1.23 V <sub>RHE</sub> ) ABPE 0.268% at 0.91 V <sub>RHE</sub> Stability test for 1 h (decayed 5.5%)	[142]
FTO/WO <sub>3</sub> /Fe <sub>2</sub> O <sub>3</sub> /Co(OH) <sub>x</sub>	Electrospray	Irregular porous skeleton morphology	1 M NaOH	450 W Xe lamp AM1.5G 100 mW cm <sup>-2</sup>	0.62 mA cm <sup>-2</sup> at 1.23 V <sub>RHE</sub> IPCE 19% at 350 nm (1.23 V <sub>RHE</sub> ) Stability test for 1 h (decayed ~33%)	[137]
FTO/WO <sub>3</sub> /Fe <sub>2</sub> O <sub>3</sub> /FeOOH	Hydrothermal	Nanorods	0.2 M Na <sub>2</sub> SO <sub>4</sub>	Xe lamp AM1.5G 100 mW cm <sup>-2</sup>	1.12 mA cm <sup>-2</sup> at 1.23 V <sub>RHE</sub> E <sub>on</sub> ≈ 0.3 V <sub>RHE</sub> ABPE 0.32% at 0.65 V <sub>RHE</sub> Stability test for 2 h (approx. const)	[165]
FTO/WO <sub>3</sub> /BiVO <sub>4</sub>	Hydrothermal	Nanorods	0.5 M KH <sub>2</sub> PO <sub>4</sub>	500 W Xe lamp 100 mW cm <sup>-2</sup>	1.56 mA cm <sup>-2</sup> at 1.23 V <sub>RHE</sub> E <sub>on</sub> ≈ 0.4 V <sub>RHE</sub> IPCE ~40% at 350 nm (1.23 V <sub>RHE</sub> ) Stability test for 2 h (decayed 10%)	[122]
FTO/WO <sub>3</sub> /BiVO <sub>4</sub> /Co-Pi	Spin coating	Nanoplates	0.1 M KPi	500 W Xe lamp AM1.5G 100 mW cm <sup>-2</sup>	1.8 mA cm <sup>-2</sup> at 1.23 V <sub>RHE</sub> IPCE ~60% at 360 nm (1.23 V <sub>RHE</sub> ) ABPE 0.6% at 0.75 V <sub>RHE</sub> Stability test for 0.33 h (decayed ~30%)	[166]
FTO/WO <sub>3</sub> /BiVO <sub>4</sub> /ZnO	Hydrothermal	Nanoplates	0.5 M Na <sub>2</sub> SO <sub>4</sub>	300 W Xe lamp AM1.5G 100 mW cm <sup>-2</sup>	2.96 mA cm <sup>-2</sup> at 1.23 V <sub>RHE</sub> E <sub>on</sub> = 0.3 V <sub>RHE</sub> IPCE ~72.8% at 380 nm (1.23 V <sub>RHE</sub> ) Stability test for 6 h (decayed 9%)	[147]
FTO/WO <sub>3</sub> /BiVO <sub>4</sub>	Hydrothermal	Blocks	0.5 M KPi pH≈7.2	150 W Xe lamp AM1.5G 100 mW cm <sup>-2</sup>	High Δj <sub>ph</sub> between 0.8–1.2 V <sub>RHE</sub> E <sub>on</sub> = 0.868 V <sub>RHE</sub> IPCE ~37% at 440 nm	[167]
FTO/WO <sub>3</sub> /Mo:BiVO <sub>4</sub> /NiOOH/FeOOH	Drop-casting	Porous structure	0.5 M Na <sub>2</sub> SO <sub>4</sub> + 0.1 M Na <sub>2</sub> SO <sub>3</sub>	AM1.5G 100 mW cm <sup>-2</sup>	5.8 mA cm <sup>-2</sup> at 1.23 V <sub>RHE</sub> IPCE ~95% at 400–450 nm (1.23 V <sub>RHE</sub> ) Stability test for 2 h (decayed 3%)	[148]
FTO/WO <sub>3</sub> /BiVO <sub>4</sub> /BiFeO <sub>3</sub>	Sol-gel	Planar surface	0.5 M Na <sub>2</sub> SO <sub>4</sub>	Xe lamp AM1.5G 100 mW cm <sup>-2</sup>	46.9 mA cm <sup>-2</sup> at 2.53 V <sub>RHE</sub> E <sub>on</sub> = 0.5 V <sub>RHE</sub> Stability test for 0.83 h (decayed 30%)	[168]
SLG/SnO <sub>2</sub> /WO <sub>3</sub> /BiVO <sub>4</sub>	Electrodeposition	Not informed	0.1 M Na <sub>2</sub> SO <sub>4</sub>	Xe lamp 100 mW cm <sup>-2</sup>	~0.7 mA cm <sup>-2</sup> at 0.8 V <sub>Ag/AgCl</sub> EQE ~70% at ~250–300 nm (0.8 V <sub>Ag/AgCl</sub> )	[169]
FTO/WO <sub>3</sub> /BiVO <sub>4</sub> /NiTCPP	Spin coating	Nanostructures	0.1 M Na <sub>2</sub> SO <sub>4</sub>	500 W Xe lamp AM1.5G 100 mW cm <sup>-2</sup>	0.26 mA cm <sup>-2</sup> at 0.6 V <sub>RHE</sub> ABPE 0.25% at 0.82 V <sub>RHE</sub> Stability test for 0.25 h (decayed > 50%)	[170]

(continued on next page)

Table 7 (continued)

Material	WO <sub>3</sub> fabrication method	WO <sub>3</sub> morphology	Electrolyte	Illumination	Notable PEC results	Ref.
FTO/WO <sub>3</sub> /BiVO <sub>4</sub>	Spin coating	Not informed	0.5 M Na <sub>2</sub> SO <sub>4</sub>	AM1.5G 100 mW cm <sup>-2</sup>	~0.6 mA cm <sup>-2</sup> at 1.23 V <sub>RHE</sub> IQE ~24% at 360 nm (1.23 V <sub>RHE</sub> )	[171]
FTO/WO <sub>3</sub> /BiVO <sub>4</sub>	Hydrothermal	Nanorods	0.5 M KPi pH 7 + 0.1 M Na <sub>2</sub> SO <sub>3</sub>	AM1.5G 100 mW cm <sup>-2</sup>	4.15 mA cm <sup>-2</sup> at 1.23 V <sub>RHE</sub> IPCE 75.9% at 430 nm (1.23 V <sub>RHE</sub> ) Stability test for 7.8 h (approx. const.)	[149]
FTO/WO <sub>3</sub> /BiVO <sub>4</sub>	Hydrothermal	Nanorods	0.5 M KPi pH 7.3 + 1 M Na <sub>2</sub> SO <sub>3</sub>	Xe lamp AM1.5G 100 mW cm <sup>-2</sup>	3.87 mA cm <sup>-2</sup> at 1.23 V <sub>RHE</sub> IPCE ~70% at 400–500 nm Stability test for 6.95 h for 24 days (approx. const.)	[150]
FTO/TiO <sub>2</sub> /WO <sub>3</sub> /BiVO <sub>4</sub> /(F <sub>100</sub> H/NiOOH)	Electrodeposition	brochosomes-like	0.5 M Na <sub>2</sub> SO <sub>4</sub>	AM1.5G 100 mW cm <sup>-2</sup>	~2.47 mA cm <sup>-2</sup> at 1.23 V <sub>RHE</sub> IPCE 60.1% at 430 nm (1.23 V <sub>RHE</sub> ) Stability test for 5 h (decayed ~20%)	[172]
FTO/WO <sub>3</sub> /BiVO <sub>4</sub>	Hydrothermal	Nanoplates	0.5 M Na <sub>2</sub> SO <sub>4</sub>	AM1.5G 100 mW cm <sup>-2</sup>	1.7 mA cm <sup>-2</sup> at 1.23 V <sub>RHE</sub> IPCE 33.8% at 410 nm (1.23 V <sub>RHE</sub> ) E <sub>on</sub> = 0.15 V <sub>RHE</sub> Stability test for 2 h (decayed ~2%)	[173]
W/WO <sub>3</sub> /BiVO <sub>4</sub> /CoO <sub>x</sub>	Hydrothermal	Not informed	0.2 M Na <sub>2</sub> SO <sub>4</sub>	300 W Xe lamp AM1.5G ~80 mW cm <sup>-2</sup>	2.3 mA cm <sup>-2</sup> at 0.8 V <sub>RHE</sub> IPCE ~41% at 400 nm (1.23 V <sub>RHE</sub> ) Stability test for 0.17 h	[174]
FTO/WO <sub>3</sub> /BiVO <sub>4</sub>	Hydrothermal	Nanoflakes	0.5 M PBS pH 7.2	AM1.5G 100 mW cm <sup>-2</sup>	1.5 mA cm <sup>-2</sup> at 1.23 V <sub>RHE</sub> IPCE ~50% at 300–400 nm (0.61 V <sub>Ag/AgCl</sub> )	[175]
FTO/WO <sub>3</sub> /BiVO <sub>4</sub>	Spin coating	Worm-like	0.5 M Na <sub>2</sub> SO <sub>4</sub>	100 W LED	0.187 mA cm <sup>-2</sup> at 1.23 V <sub>RHE</sub> ABPE ~1% at ~0.7 V <sub>RHE</sub>	[176]
FTO/WO <sub>3</sub> -1D/BiVO <sub>4</sub> /Co-Pi	Flame vapour deposition	Nanowires	0.1 M KP <sub>i</sub>	300 W Xe lamp AM1.5G 100 mW cm <sup>-2</sup>	3.3 mA cm <sup>-2</sup> at 1.23 V <sub>RHE</sub> E <sub>on</sub> ≈ 0.45 V <sub>RHE</sub> IPCE 50% at 420 nm (1 V <sub>SCE</sub> ) ABPE 0.7% at 0.88 V <sub>RHE</sub>	[144]
FTO/WO <sub>3</sub> /BiVO <sub>4</sub> /TANiFe	Hydrothermal	Nanoplates	0.5 M borate Buffer pH 8.5	300 W Xe lamp AM1.5G 100 mW cm <sup>-2</sup>	3.7 mA cm <sup>-2</sup> at 1.23 V <sub>RHE</sub> IPCE 69.4% at 420 nm (1.23 V <sub>RHE</sub> ) ABPE 0.95% at 0.76 V <sub>RHE</sub> Stability test for 5 h (decayed ~15%)	[177]
FTO/(W <sub>x-0.05</sub> Mo <sub>x</sub> )O <sub>3</sub> -(Sn <sub>x-0.05</sub> Nb <sub>x</sub> )O <sub>2</sub> :N	Hydrothermal	Nanotubes	1.0 M H <sub>2</sub> SO <sub>4</sub>	Xe lamp AM1.5G 100 mW cm <sup>-2</sup>	4.13 mA cm <sup>-2</sup> at 0.1 V <sub>RHE</sub> ABPE ~8% at 0.4 V STH 3.12% Stability test for 24 h (decayed ~5%)	[178]
FTO/BiVO <sub>4</sub> -NLs/WO <sub>3</sub> -NRs	Hydrothermal	Nanorods	1.0 M Na <sub>2</sub> SO <sub>3</sub> + 0.5 M PBS pH 7.3	AM1.5G 100 mW cm <sup>-2</sup>	2.83 mA cm <sup>-2</sup> at 1.23 V <sub>RHE</sub> IPCE ~45% at 310–460 nm (1.23 V <sub>RHE</sub> )	[179]
FTO/WO <sub>3</sub> /BiVO <sub>4</sub> /NiFeCr	Sputtering	Nanoparticles	0.1 M PBS pH 6.9	AM1.5G 100 mW cm <sup>-2</sup>	4.9 mA cm <sup>-2</sup> at 1.23 V <sub>RHE</sub> IPCE ~56% at 350–470 nm (1.23 V <sub>RHE</sub> ) ABPE 0.95% at 0.85 V <sub>RHE</sub> Stability test for 6 h (decayed ~7%)	[180]
FTO/WO <sub>3</sub> /BiVO <sub>4</sub> /ZnO	Spin coating	Planar surface	0.5 M Na <sub>2</sub> SO <sub>4</sub>	Xe lamp AM1.5G 100 mW cm <sup>-2</sup>	0.19 mA cm <sup>-2</sup> at 1.23 V <sub>RHE</sub> ABPE 0.036% at 0.41 V <sub>RHE</sub> IPCE ~6% at 380 nm at 1.23 V <sub>RHE</sub> Stability test for 0.4 h (decayed ~30%)	[181]
FTO/WO <sub>3</sub> /Bi <sub>2</sub> MoO <sub>6</sub> /Co-Pi	Hydrothermal	Nanoplates	0.5 M Na <sub>2</sub> SO <sub>4</sub>	Xe lamp AM1.5G 100 mW cm <sup>-2</sup>	1.4 mA cm <sup>-2</sup> at 1.0 V <sub>Ag/AgCl</sub> IPCE ~67% at 380 nm ABPE 0.07% at 1.06 V <sub>RHE</sub> Stability test for 3 h (decayed ~4%)	[182]
FTO/WO <sub>3</sub> /BiVO <sub>4</sub> /TiO <sub>2</sub>	Hydrothermal	Nanoplates	0.5 M Na <sub>2</sub> SO <sub>4</sub>	Xe lamp AM1.5G 100 mW cm <sup>-2</sup>	1.04 mA cm <sup>-2</sup> at 1.23 V <sub>RHE</sub> IPCE ~25% at 460 nm at 1.23 V <sub>RHE</sub> Stability test for 24 h (approx. const.)	[183]
FTO/WO <sub>3</sub> /BiVO <sub>4</sub>	Sol-gel	Grains and coating-like	0.1 M KH <sub>2</sub> PO <sub>4</sub>	AM1.5G 100 mW cm <sup>-2</sup>	~2.50 mA cm <sup>-2</sup> at 1.23 V <sub>RHE</sub> IPCE ~55% at 400 nm at 1.23 V <sub>RHE</sub> Stability test for ~6 h (decayed ~60%)	[184]

Table 7 (continued)

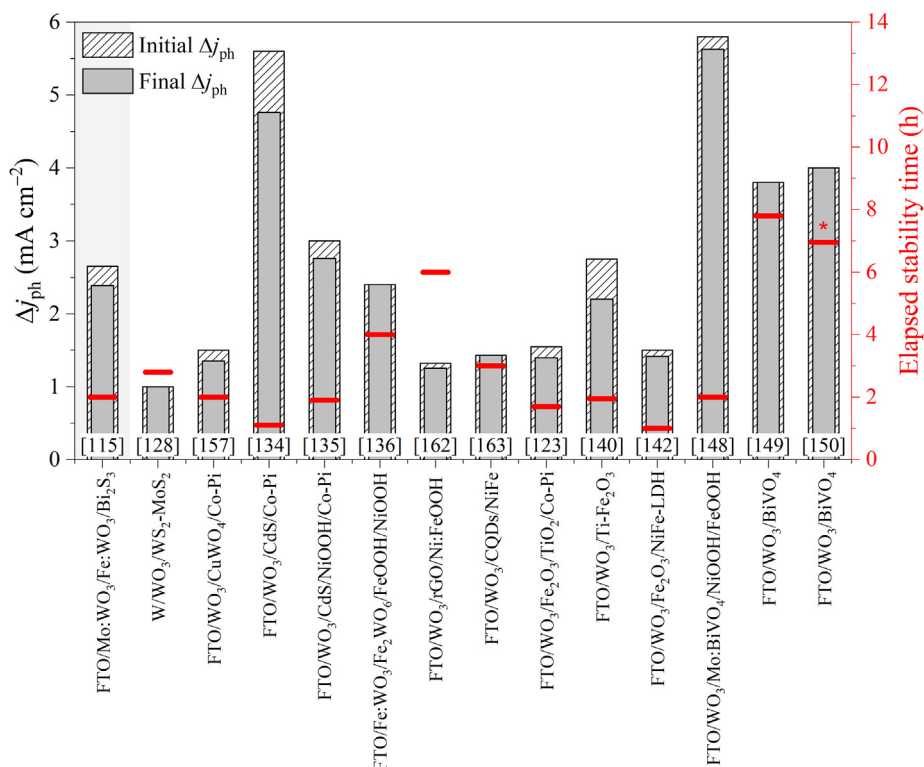
Material	WO <sub>3</sub> fabrication method	WO <sub>3</sub> morphology	Electrolyte	Illumination	Notable PEC results	Ref.
FTO/WO <sub>3</sub> /ZnWO <sub>4</sub>	Hydrothermal	Nanorods	0.5 M Na <sub>2</sub> SO <sub>4</sub>	Xe lamp AM1.5G 100 mW cm <sup>-2</sup>	2.53 mA cm <sup>-2</sup> at 1.23 V <sub>RHE</sub> IPCE ~48% at 465 nm Stability test for ~0.11 h (approx. const.)	[185]
WO <sub>3</sub> /CuO	Hydrothermal	Nanoparticles	0.5 M Na <sub>2</sub> SO <sub>4</sub>	AM1.5G 100 mW cm <sup>-2</sup>	3.2 mA cm <sup>-2</sup> at 1.23 V <sub>RHE</sub> Stability test for 50 h (decayed ~12%)	[186]
FTO/WO <sub>3</sub> /BiVO <sub>4</sub>	Spray coating	Compact film	0.1 M Na <sub>2</sub> HPO <sub>4</sub> + 0.5 M Na <sub>2</sub> SO <sub>4</sub>	100 W Xe lamp AM1.5G 100 mW cm <sup>-2</sup>	2.1 mA cm <sup>-2</sup> at 1.23 V <sub>RHE</sub> Stability test for 2 h (decayed 46%)	[151]
FTO/WO <sub>3</sub> /BiVO <sub>4</sub>	Sputtering using the GLAD	Nanorods	0.5 M Na <sub>2</sub> SO <sub>4</sub> pH 7	AM1.5G 100 mW cm <sup>-2</sup>	2.24 mA cm <sup>-2</sup> at 1 V <sub>Ag/AgCl</sub> E <sub>on</sub> = 0.42 V <sub>Ag/AgCl</sub>	[187]
FTO/WO <sub>3</sub> /WS <sub>2</sub>	Hydrothermal	Nanorods	0.3 M KH <sub>2</sub> PO <sub>4</sub>	150 W Xe lamp AM1.5G 100 mW cm <sup>-2</sup>	~0.5 mA cm <sup>-2</sup> at ~1.2 V <sub>RHE</sub>	[188]
FTO/WO <sub>3</sub> /CdS	Hydrothermal	Not informed	0.2 M Na <sub>2</sub> SO <sub>4</sub> pH 0.69	500 W Xe lamp AM1.5G 100 mW cm <sup>-2</sup>	2.13 mA cm <sup>-2</sup> at 1.23 V <sub>RHE</sub> ABPE 0.74% at 0.39 V <sub>RHE</sub> Stability test for 0.083 h	[189]
FTO/WO <sub>3</sub> /TiO <sub>2</sub> /CQDs	Hydrothermal	Nanoplates	0.2 M Na <sub>2</sub> SO <sub>4</sub>	300 W Xe lamp AM1.5G 100 mW cm <sup>-2</sup>	2.03 mA cm <sup>-2</sup> at 1.23 V <sub>RHE</sub> ABPE 0.33% at ~0.9 V <sub>RHE</sub> IPCE ~62.3% at 340 nm (1.23 V <sub>RHE</sub> ) Stability test for 5.6 h (decayed 51.8%)	[190]
FTO/WO <sub>3</sub> /prussian blue	Hydrothermal	Nanorods	0.1 M Na <sub>2</sub> SO <sub>4</sub> pH 7	300 W Xe lamp	0.34 mA cm <sup>-2</sup> at 1.23 V <sub>RHE</sub> IPCE 18% at 350 nm (1.23 V <sub>RHE</sub> ) Stability test for ~1.4 h (decayed ~9%)	[191]
FTO/WO <sub>3</sub> /BiVO <sub>4</sub> /Fe <sub>2</sub> O <sub>3</sub>	PLD	Not informed	0.5 M Na <sub>2</sub> SO <sub>4</sub> + 0.5 M Na <sub>2</sub> SO <sub>3</sub>	AM1.5G 100 mW cm <sup>-2</sup>	~2.8 mA cm <sup>-2</sup> at 1.23 V <sub>RHE</sub> E <sub>on</sub> = ~0.3 V <sub>RHE</sub> IPCE ~10.5% at 350 nm (0.6 V <sub>RHE</sub> ) Stability test for 16 h (approx. const.)	[192]
FTO/WO <sub>3</sub> /Yb-Mo-BiVO <sub>4</sub>	Drop-cast	Irregular rod-shaped	1 M K <sub>2</sub> HPO <sub>4</sub> pH 8.7	150 W Xe lamp 130 mW cm <sup>-2</sup>	1.67 mA cm <sup>-2</sup> at 0.85 V <sub>SCE</sub> ABPE 0.81% at 0.85 V <sub>SCE</sub> Stability test for 1 h (approx. const.)	[193]
WO <sub>3</sub> /S:Bi <sub>2</sub> O <sub>3</sub> /(Ga,W):BiVO <sub>4</sub> /Co-Pi	Spray coating	Nanopores	0.1 M KPi	Xe lamp AM1.5G 100 mW cm <sup>-2</sup>	5.1 mA cm <sup>-2</sup> at 1.23 V <sub>RHE</sub> IPCE ~72% at 460 nm (1.23 V <sub>RHE</sub> ) Stability test for 10 h (decayed ~10%)	[194]
Ti/WO <sub>3</sub> /Mo:BiVO <sub>4</sub>	Spin coating	Nanoparticles	0.1 M H <sub>2</sub> SO <sub>4</sub>	300 W Xe lamp 39.5 mW cm <sup>-2</sup>	2.5 mA cm <sup>-2</sup> at 1.23 V <sub>RHE</sub> IPCE ~20% at 300–400 nm (1.23 V <sub>RHE</sub> ) Stability test for 2 h (decayed ~50%)	[195]
FTO/WO <sub>3</sub> /NiFe-LDH	Hydrothermal/ Electrodeposition	Nanoparticles	0.1 M Na <sub>2</sub> SO <sub>4</sub> + 0.1 M KPi	Xe lamp AM1.5G 100 mW cm <sup>-2</sup>	2.5 mA cm <sup>-2</sup> at 1.23 V <sub>RHE</sub> ABPE 0.26% at 0.97 V <sub>RHE</sub> Stability test for 3.5 h (approx. const.)	[196]
ITO/WO <sub>3</sub> /Cu <sub>2</sub> O/CuO	Hydrothermal/ Electrodeposition	Cubic grains	0.5 M Na <sub>2</sub> SO <sub>4</sub>	300 W Xe lamp AM1.5G 100 mW cm <sup>-2</sup>	4.7 mA cm <sup>-2</sup> at 1.23 V <sub>RHE</sub> Stability test for 3 h (decayed ~21%)	[197]
FTO/WO <sub>3</sub> /BiFeO <sub>3</sub>	Hydrothermal/Spin coating	Nanoplates	0.1 M Na <sub>2</sub> SO <sub>4</sub>	300Xe lamp AM1.5G 100 mW cm <sup>-2</sup>	2.8 mA cm <sup>-2</sup> at 0.6 V <sub>Ag/AgCl</sub> Stability test for 0.1 h (decayed ~10%)	[198]
W/WO <sub>3</sub> /BiVO <sub>4</sub> /Co-Pi	Hydrothermal	Nanoflakes	0.1 M Na <sub>2</sub> SO <sub>4</sub> + 0.1 M KPi	500Xe lamp AM1.5G 100 mW cm <sup>-2</sup>	2.3 mA cm <sup>-2</sup> at 1.23 V <sub>RHE</sub> ABPE 0.38% at 0.88 V <sub>RHE</sub> Stability test for 10 h (decayed ~9%)	[199]

Lee and co-workers manufactured  $\text{WO}_3/\text{BiVO}_4$  core-shell nanorod arrays via an all-solution-processed methodology [149]. The vertically aligned  $\text{WO}_3$  nanorods were obtained on a FTO substrate by the hydrothermal method without the presence of a seed layer and  $\text{BiVO}_4$  was deposited by pulsed electrodeposition at  $80^\circ\text{C}$ . Regarding the PEC assessment of this system, it was performed employing sodium sulfite ( $\text{Na}_2\text{SO}_3$ ) in the electrolyte solution as a hole scavenger because its oxidation is thermodynamically and kinetically more favourable than the oxidation of water, which allows comparison of the  $\Delta j_{\text{ph}}$  obtained from the oxidation of water without the kinetic impediments [145,149]. Increasing the  $\text{WO}_3$  hydrothermal synthesis temperature from  $120$  to  $170^\circ\text{C}$ , the authors noted that the  $\Delta j_{\text{ph}}$  increased up to  $1.97\text{ mA cm}^{-2}$  at  $1.23\text{ V}_{\text{RHE}}$  due to enlargement of the nanorods of  $\text{WO}_3$ , suggesting an increase in active sites on the nanorods. However, the  $\Delta j_{\text{ph}}$  decreased to  $1.58\text{ mA cm}^{-2}$  at  $1.23\text{ V}_{\text{RHE}}$  at higher synthesis temperatures ( $180^\circ\text{C}$ ), and it was assigned to the occurrence of  $\text{WO}_3$  bulky rods grown between small nanorods that blocked light and prevented the small nanorods from producing photogenerated charge carriers. The number of deposition cycles of  $\text{BiVO}_4$  layer onto  $\text{WO}_3$  films was systematically evaluated and 9 cycles were found to be the optimized condition. Deposition cycles above 9 resulted in diminished  $\Delta j_{\text{ph}}$  due to the increase in the thickness of the  $\text{BiVO}_4$  film and its short diffusion length, which led to increased recombination of electron-hole pairs. In terms of photoresponse, the optimized  $\text{WO}_3/\text{BiVO}_4$  photoanode reached a  $\Delta j_{\text{ph}}$  of  $4.15\text{ mA cm}^{-2}$  at  $1.23\text{ V}_{\text{RHE}}$  in  $0.5\text{ M}$  phosphate buffer solution (PBS) pH 7 with  $1\text{ M Na}_2\text{SO}_3$ . Concerning the stability test, the  $\Delta j_{\text{ph}}$  of the bare pristine  $\text{WO}_3$  decreased constantly from the beginning of the test, and the  $\text{WO}_3$  nanorod array was peeled off after 4 h of measurement. On the other hand, the optimized  $\text{WO}_3/\text{BiVO}_4$  system remained stable for 8 h of the experiment. This implies that without the presence of a seed layer,  $\text{WO}_3$  was weakly adhered to the FTO surface, whereas  $\text{BiVO}_4$  covered the entire surface of

the  $\text{WO}_3$  film in a core-shell structure and behaved like a passivation layer.

Employing a similar synthesis approach, Kim and co-workers also obtained  $\text{WO}_3/\text{BiVO}_4$  system, which particularly differed compared to the study above regarding using a  $\text{WO}_3$  seed layer deposited on FTO substrate followed by growth of  $\text{WO}_3$  nanorods by hydrothermal method [150]. A second step of the hydrothermal treatment allowed the growth of branches on  $\text{WO}_3$  nanorods using the same precursor reagents. The authors achieved excellent long-term stability of the system by monitoring the  $\Delta j_{\text{ph}}$  for 6.9 h at  $1.23\text{ V}_{\text{RHE}}$ . The experiment was also monitored for 24 days and showed no significant degradation, meaning the branched  $\text{WO}_3\text{ NR}/\text{BiVO}_4$  system is greatly stable for PEC performance.

Employing a different synthesis route, Coelho and co-workers electrodeposited a Bi layer on  $\text{WO}_3$  films (obtained by spray coating using an airbrush) and that was subsequently converted to the  $\text{BiVO}_4$  by the drop-casting addition of  $\text{NH}_4\text{VO}_3$  and heat treatment [151]. The number of layers of  $\text{WO}_3$  spray deposition was studied, as well as the electrodeposition of Bi. In the first case, increasing the number of layers allowed higher  $\Delta j_{\text{ph}}$  to be reached for bare  $\text{WO}_3$ , however, the same was not observed for the  $\text{WO}_3/\text{BiVO}_4$  heterojunction, which lost its photoelectrocatalytic performance. After reaching an optimized  $\text{WO}_3$  condition, the electrodeposition of metallic Bi as a precursor of  $\text{BiVO}_4$  proved to be the best strategy compared to other methodologies of obtaining the heterostructure, such as spin coating and drop-casting. To complete the synthesis, the pulsed Bi electrodeposition ensured a better performance of the heterostructure than that performed continuously with the same deposition charge. In terms of photoresponse for OER, the  $\text{FTO}/\text{WO}_3/\text{BiVO}_4$  reached a  $\Delta j_{\text{ph}}$  of  $2.1\text{ mA cm}^{-2}$  at  $1.23\text{ V}_{\text{RHE}}$ . Regarding the charge transfer dynamics for  $\text{WO}_3/\text{BiVO}_4$ , further understanding of this phenomenon in the  $\text{WO}_3/\text{BiVO}_4$  system has been achieved by the transient absorption (TA) mid-infrared (mid-IR) spectroscopy in the picosecond to microsecond time scale



**Fig. 16.** Elapsed stability time and initial and final  $\Delta j_{\text{ph}}$  values were achieved before and after the stability test, respectively, at  $1.23\text{ V}_{\text{RHE}}$  for the most recent homo- and heterojunction-based  $\text{WO}_3$  photoanodes. The presented values of  $\Delta j_{\text{ph}}$  correspond to approximations based on the elapsed stability tests from their initial and final values. \*The experiment was monitored for 24 days.

[152]. Employing the nanosecond mid-IR TA experiments, it was able to confirm that charge carrier separation takes place in the  $\text{WO}_3/\text{BiVO}_4$  system under visible light excitation and it persists up to the microsecond time scale. Furthermore, trapping and recombination of the photogenerated electrons in the  $\text{BiVO}_4$  can be avoided by the flow of them into  $\text{WO}_3$  where they live longer. In other words, the key role of  $\text{WO}_3$  is to extend the photogenerated electrons' lifetime in the  $\text{WO}_3/\text{BiVO}_4$  heterojunction [152].

A summary of the most recent heterostructure-based  $\text{WO}_3$  films for PEC water splitting is shown in Table 7.

At last, aiming to seek a possible general trending of the photoresponse, i.e.,  $\Delta j_{\text{ph}}$  at 1.23  $V_{\text{RHE}}$ , before and after elapsed stability time for  $\text{WO}_3$ -based heterojunctions, some of the most relevant data listed in Table 7 were arranged in Fig. 16. As a reminder, the compiled PEC data in Fig. 16 is to observe a probable trend of the PEC response as a function of  $\text{WO}_3$ -heterojunctions. We have no intention of systematically comparing these data as each system has unique surface characteristics and the PEC experiments were performed under different conditions (e.g., electrolyte and power of lamps). Having that being reminded, it is possible to observe from Fig. 16 that the FTO/ $\text{WO}_3$ /CdS/Co-Pi delivered one of the highest initial and final  $\Delta j_{\text{ph}}$  values. Despite the outstanding generated photoresponse for water splitting, such a system features as a drawback the considerable toxicity of cadmium, which goes against the idea of constructing a green photocatalyst. Another heterostructure system reviewed here with considerable  $\Delta j_{\text{ph}}$  response and stability is the one comprised of  $\text{WO}_3$  and  $\text{BiVO}_4$  ( $\text{WO}_3/\text{BiVO}_4$ ). The  $\text{WO}_3/\text{BiVO}_4$  heterostructure stands out to be more attractive in terms of being a green system with earth-abundant elements and having suitable optoelectronic properties for light-driven water splitting. Even with no additional junctions, the combination of  $\text{WO}_3$  and  $\text{BiVO}_4$  reached a remarkable  $\Delta j_{\text{ph}}$  of ca.  $4.0 \text{ mA cm}^{-2}$  at 1.23  $V_{\text{RHE}}$  and enabled performing stability experiment for up to 8 h under continuous illumination and polarization. In this sense, the combination of other green catalysts with the  $\text{WO}_3/\text{BiVO}_4$  heterostructure seems to be a promisor option to be further investigated, since the highest  $\Delta j_{\text{ph}}$  before and after elapsed stability time (cf. Fig. 16) was for the FTO/ $\text{WO}_3$ /Mo:BiVO<sub>4</sub>/NiOOH/FeOOH system.

#### 4. Conclusions and perspective

The fundamental study about the improvement of the water splitting reaction to obtain renewable and sustainable energy sources is based on the development of low-cost, efficient, stable, and photoactive catalysts. For that,  $\text{WO}_3$  semiconductor is a potential photoanode material due to its intrinsic characteristics concerning a narrow  $E_g$  in the visible range (around 2.4 eV),  $E_{\text{VB}}$  sufficiently more positive than the potential for water oxidation, resistance against photocorrosion in aqueous solutions, and a long hole diffusion length ( $\sim 150 \text{ nm}$ ) [4]. However, the  $\text{WO}_3$  semiconductor presents high recombination of the charge carriers and a relatively high overpotential for water oxidation. In light of these, this review brings many recent arrangements possibilities and other strategies to improve the  $\text{WO}_3$  efficiency. This work also aimed to review the most recent studies about the influence of the  $\text{WO}_3$  morphology (Table 1) and crystal plane growth (Table 2), the defect engineering based on oxygen vacancies (Table 3), and the modifications, such as doping (Table 4), decorations (Table 5), and homo (Table 6) and heterojunctions (Table 7) for solar-driven water splitting application.

Most papers in the literature seek only a high  $\Delta j_{\text{ph}}$  and good stability, nevertheless few ones have reported on ABPE values. The latter involves both the importance of the  $\Delta j_{\text{ph}}$  and the  $E_{\text{on}}$  so that ABPE combined with stability would be an excellent parameter to

verify the best strategies employed. From this point of view, papers based on heterojunctions are the ones that most describe these parameters and are highlighted among the others for presenting excellent results [127,134–136,144,177,180]. However, based on the comparison of the  $\Delta j_{\text{ph}}$  response of a variety of  $\text{WO}_3$ -based systems for water oxidation, it is possible to infer that the combination of a desired morphology and crystal plane with a heterojunction can bring higher photoelectroactivity with good stability for water splitting reaction [148–150,186,194,197]. The improvement of water photooxidation was more pronounced when multijunctions were applied [168]. However, the choice of the second semiconductor (or more than one) that will be used in a  $\text{WO}_3$ -based heterojunction needs to be carefully considered. Some of the modifications reported in the literature caused a decrease in the  $\Delta j_{\text{ph}}$  reaching values that are even lower than the pure  $\text{WO}_3$  photoanode [170,176,181,191]. In this sense, the junctions applied in the  $\text{WO}_3$  photoanode must be adjusted to obtain an efficient energetic coupling of the band edges of all the semiconductors taking into consideration as well as the redox couple potential in the electrolyte to minimize the recombination losses or losses across the interfaces. Another important and recurring aspect in papers on photoelectrodes applied to light-driven water splitting is the lack of information and clarity about the stability data. This is one of the most relevant results in this area and is often neglected, as can be seen in this review when approaching recent works. Such data must be quantified correctly and presented clearly for possible comparison between the PECs systems. This practice is already happening in highly relevant papers and should become a priority in the presentation of data.

At last, as it is already known, engineering nanoarchitectures is a great option to increase the  $\Delta j_{\text{ph}}$  of photocatalysts, and it is not different for  $\text{WO}_3$ . In this regard, it is necessary to seek nanostructures and properties that can maximize the performance and reliability to obtain the most successful material, also taking into consideration the necessary junctions and modifications, which are essential for an efficient water splitting process. No less important than designing a better electrode, the optimization of the device that will be used in this reaction is extremely important, and sometimes, neglected. Only when those two points were aligned is that the solar-driven water splitting will become a real option for energy production in a large-scale process.

#### Declaration of Competing Interest

The authors declare that they have no known competing financial interests or personal relationships that could have appeared to influence the work reported in this paper.

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